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L14
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L21	32934 SEA ABB=ON PLU=ON L19 OR L20
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	865888-37-5/BI OR 95-54-5/BI)
L27	2 SEA ABB=ON PLU=ON L26 AND L3 D RN
L28	2 SEA SUB=L3 SSS FUL L24
	D SCA
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L29 L30	3 SEA ABB=ON PLU=ON L28 33 SEA ABB=ON PLU=ON L22 (L) L21
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FILE HOME

FILE REGISTRY

Property values tagged with IC are from the ZIC/VINITI data file provided by InfoChem.

STRUCTURE FILE UPDATES: 24 NOV 2008 HIGHEST RN 1075293-66-1 DICTIONARY FILE UPDATES: 24 NOV 2008 HIGHEST RN 1075293-66-1

New CAS Information Use Policies, enter HELP USAGETERMS for details.

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Please note that search-term pricing does apply when conducting SmartSELECT searches.

REGISTRY includes numerically searchable data for experimental and predicted properties as well as tags indicating availability of experimental property data in the original document. For informatio on property searching in REGISTRY, refer to:

http://www.cas.org/support/stngen/stndoc/properties.html

FILE STNGUIDE

FILE CONTAINS CURRENT INFORMATION.

LAST RELOADED: Nov 21, 2008 (20081121/UP).

FILE HCAPLUS

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FILE COVERS 1907 - 25 Nov 2008 VOL 149 ISS 22 FILE LAST UPDATED: 24 Nov 2008 (20081124/ED)

HCAplus now includes complete International Patent Classification (I reclassification data for the third quarter of 2008.

New CAS Information Use Policies, enter HELP USAGETERMS for details.

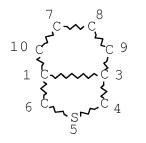
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10593498

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NEW CAS INFORMATION USE POLICIES, ENTER HELP USAGETERMS FOR DETAILS.

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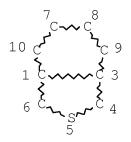
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STEREO ATTRIBUTES: NONE

=> d que stat 128

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10593498

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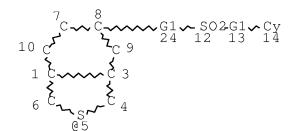
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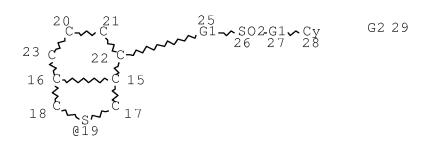
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L3 388 SEA FILE=REGISTRY SSS FUL L2 AND L1

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DEFAULT MLEVEL IS ATOM

GGCAT IS UNS AT 14

GGCAT IS UNS AT 28

DEFAULT ECLEVEL IS LIMITED

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STEREO ATTRIBUTES: NONE

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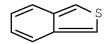
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2 ANSWERS

SEARCH TIME: 00.00.01

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L30 ANSWER 28 OF 33 HCAPLUS COPYRIGHT 2008 ACS on STN AN 1995:498326 HCAPLUS Full-text DN122:251969 OREF 122:45757a,45760a Antistatic silver halide photographic material ΤI Tachibana, Noriki; Morita, Seiwa IN Konishiroku Photo Ind, Japan PASO Jpn. Kokai Tokkyo Koho, 47 pp. CODEN: JKXXAF DT Patent LA Japanese FAN.CNT 1 PATENT NO. DATE KIND DATE APPLICATION NO. _____ ____ PΙ JP 06301154 A 19941028 JP 1993-87395 199304 14 19930414 PRAI JP 1993-87395 AB In the title Aq halide photoq, material utilizing ≥ 1 antistatic layers containing an electronically conductive polymer, the above polymer is crosslinked with a crosslinking agent selected from an epoxy-, aldehyde-, reactive ethylene-, ethyleneimine-, reactive ester-type material. ΤТ 91201-85-3 133150-75-1 133184-17-5 162370-00-5 RL: DEV (Device component use); TEM (Technical or engineered material use); USES (Uses) (electronically conductive polymer; antistatic photog. film using) RN 91201-85-3 HCAPLUS CN Benzo[c]thiophene, homopolymer (CA INDEX NAME) CM CRN 270-82-6 CMF C8 H6 S



RN 133150-75-1 HCAPLUS

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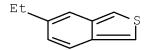
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RN 133184-17-5 HCAPLUS

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CM 1

CRN 133184-16-4 CMF C10 H10 S



RN 162370-00-5 HCAPLUS

CN Benzo[c]thiophene, 5-[(octyloxy)methyl]-, homopolymer (9CI) (CA INDEX NAME)

CM 1

CRN 162369-99-5 CMF C17 H24 O S

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        (electronically conductive polymer;
        antistatic photog. film using)
L30
     ANSWER 1 OF 33 HCAPLUS
                             COPYRIGHT 2008 ACS on STN
ΑN
     2008:1102650 HCAPLUS Full-text
DN
     149:368039
ΤI
     Electrically conductive polymeric elastomer composition for
     electromagnetic wave shield
     Hamano, Shokichi; Sato, Tomonori; Tanami, Shiro
IN
PΑ
     Kyodo Giken Chemical Co., Ltd., Japan
SO
     PCT Int. Appl., 31pp.
     CODEN: PIXXD2
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DT
LA
     Japanese
FAN.CNT 1
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             TZ, UG, ZM, ZW, AM, AZ, BY, KG, KZ, MD, RU, TJ, TM
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PRAI JP 2007-54746 A 20070305

Disclosed is a transparent, composite, elec. conductive polymeric elastomer composition which can keep its electromagnetic wave shielding property and has an excellent light transmission property. Specifically disclosed is a transparent elastomer which is intended to be closely arranged on a display on the side of a viewer. The transparent elastomer comprises: an elec. conductive particle complex which comprises multiple elec. conductive metal particles and an elec. conductive organic polymer with which the metal particles are coated, and which causes the metal particles to be crosslinked to thereby form a three-dimensional network structure; and an elec. non-conductive organic polymer which acts as a binder for keeping the three-dimensional structure of the elec. conductive particle complex.

IT 91201-85-3, Polyisothianaphthene

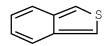
RL: NUU (Other use, unclassified); USES (Uses) (composition containing; elec. conductive polymeric elastomer composition for electromagnetic wave shield)

RN 91201-85-3 HCAPLUS

CN Benzo[c]thiophene, homopolymer (CA INDEX NAME)

CM 1

CRN 270-82-6 CMF C8 H6 S



CC 76-1 (Electric Phenomena) Section cross-reference(s): 38, 56, 73 79-10-7, Acrylic acid, uses 80-62-6, Methyl methacrylate ΙT 103-11-7, 2-Ethylhexylacrylate 140-88-5, Ethyl acrylate 141-32-2, Butyl acrylate 7440-02-0, Nickel, uses 7440-22-4, 7440-50-8, Copper, uses 13463-39-3, Nickel carbonyl Silver, uses 25233-34-5, Polythiophene 30604-81-0, Polypyrrole 91201-85-3, Polyisothianaphthene 126213-51-2, Polyethylenedioxythiophene RL: NUU (Other use, unclassified); USES (Uses) (composition containing; elec. conductive polymeric elastomer composition for electromagnetic wave shield)

REI	ABLE
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Fuji Photo Film Co Ltd | 2004 | |JP 2004281941 A Kawamura Institute Of C|2001 | |JP 2001316595 A | HCAPLUS Nitto Denko Corp 12006 I |WO 2006043448 A1 | HCAPLUS Nitto Denko Corp |2006 | |JP 2006119348 A | HCAPLUS Sanyo Chemical Industri | 2005 | JP 2005093609 A | HCAPLUS

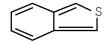
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- AN 2007:914056 HCAPLUS Full-text
- DN 148:145040
- TI Low bandgap conducting polymers
- AU Rasmussen, Seth C.; Pomerantz, Martin
- CS Department of Chemistry and Molecular Biology, North Dakota State University, Fargo, ND, USA
- SO Handbook of Conducting Polymers (3rd Edition) (2007), Volume 1, 12/1-12/42. Editor(s): Skotheim, Terje A.; Reynolds, John R. Publisher: CRC Press LLC, Boca Raton, Fla. CODEN: 69JQUE
- DT Conference; General Review
- LA English
- AB A review. Quantum mech. calcns., poly(isothianaphthene) and related fused-ring polymers and their copolymers, polythienothiophene and related systems, donor-acceptor low-bandgap polymers, poly(dithienylethylene) and related systems, poly(thiophene methine) polymers, and other low-bandgap polymers are described.
- IT 91201-85-3, Poly(isothianaphthene)
 - RL: PRP (Properties)

(low-bandgap conducting polymers)

- RN 91201-85-3 HCAPLUS
- CN Benzo[c]thiophene, homopolymer (CA INDEX NAME)

CM 1

CRN 270-82-6 CMF C8 H6 S



Burbridge, S

CC

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91201-85-3, Poly(isothianaphthene)
ΙT
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        (low-bandgap conducting polymers)
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Ajayaghosh, A
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                                         |Electrochim Acta
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Du Bois, C	2001	119	321	Synth Met	HCAPLUS
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Kalaji, M	1999	101	123	· <u> -</u>	HCAPLUS
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Kertesz, M	1998	39	76	Polym Prepr (Am Chem	HCAPLUS
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Kiebooms, R	11997	184	189	·	HCAPLUS
Kiebooms, R	11999	1101	40	_	HCAPLUS
Kim, I		44	11163	Polym Prepr (Am Chem	
King, G	11995	15	1447		HCAPLUS
King, G Kitamura, C	11996	8	1570	•	HCAPLUS
	11994	10	1585		
Kitamura, C	•	100	•	J Chem Soc Chem Comm	
Kobayashi, M	1985	82	5717	·	HCAPLUS
Krajcovic, J	1999	105	79	· · · ·	HCAPLUS
Kumar, A	2006	39	2723		HCAPLUS
Kumar, A	2005	46	1969	Polym Prepr (Am Chem	
Kwon, O	2000	104	7106	· ·	HCAPLUS
Lambert, T	1991		752	J Chem Soc Chem Comm	
Lee, B	2005	17	1792	Adv Mater	HCAPLUS
Lee, B	2002	43	568	Polym Prepr (Am Chem	HCAPLUS
Lee, B	2005	46	1010	Polym Prepr (Am Chem	HCAPLUS
Lee, B	2005	46	860	Polym Prepr (Am Chem	HCAPLUS
Lee, K	2001	34	5746	Macromolecules	HCAPLUS
Lee, Y	2001	13	2234	Chem Mater	HCAPLUS
Lee, Y	2001	119	77	Synth Met	HCAPLUS
Loganathan, K	2003	15	1918	Chem Mater	HCAPLUS
Lorcy, D	1992	4	562	Adv Mater	HCAPLUS
McCullough, R	1998	i	225	Handbook of conducti	
Meng, H	2003	115	146		HCAPLUS
Meng, H	2001	34	1810	•	HCAPLUS
Mills, C		1102	1000		HCAPLUS
Musmanni, S	11993	1	1172	J Chem Soc Chem Comm	
Nayak, K	11990	123	2237		HCAPLUS
Neef, C	11990	123	12237		
					HCAPLUS
Neugebauer, H		110		_	HCAPLUS
Neugebauer, H	2004	563	153	J Electroanal Chem	HCAPLUS

Neugebauer, H	2003	139	747	Synth Met	HCAPLUS
Ottenbourgs, B	11997	89	195	Synth Met	HCAPLUS
Paulussen, H	11997	138	5221	Polymer	HCAPLUS
Paulussen, H	12001	41	3121	Polymer	İ
Paulussen, H	1997	84	415	Synth Met	HCAPLUS
Perepichka, I	2004	114	1679	J Mater Chem	HCAPLUS
Polec, I	2003	41	1034	J Polym Sci Part A P	
Pomerantz, M	1998	İ	277	Handbook of conducti	
Pomerantz, M	11992	İ	1672	J Chem Soc Chem Comm	•
Pomerantz, M	2001	34	1817	Macromolecules	HCAPLUS
Pomerantz, M	1993	55	1960	Synth Met	HCAPLUS
Pomerantz, M	11997	84	243	Synth Met	HCAPLUS
Quattrocchi, C	11993	26	1260	Macromolecules	HCAPLUS
Quattrocchi, C	11993	155-57		Synth Met	İ
Roncali, J	11997	97	173	Chem Rev	HCAPLUS
Roncali, J	11994	İ	2249	J Chem Soc Chem Comm	· ·
Sannicolo, F	11998	110	2167	Chem Mater	HCAPLUS
Schlick, U	11998	92	75	Synth Met	HCAPLUS
Seshadri, V	2004	16	5644	Chem Mater	HCAPLUS
Seshadri, V	12003	19	9479	Langmuir	HCAPLUS
Seshadri, V	12003	88	292	Polym Mater Sci Eng	HCAPLUS
Shaheen, S	2001	121	1583	Synth Met	HCAPLUS
Sonmez, G	2004	16	1905	Adv Mater	HCAPLUS
Sonmez, G	12005	117	897	Adv Mater	HCAPLUS
Sonmez, G	2004	143	11498	Angew Chem Int Ed	HCAPLUS
Sonmez, G	2003	115	14923	Chem Mater	HCAPLUS
Sonmez, G	2005	38	1669	Macromolecules	HCAPLUS
Sotzing, G	1996	8	882	Chem Mater	HCAPLUS
Sotzing, G	1995	1	703	J Chem Soc Chem Comm	HCAPLUS
Sotzing, G	1998	31	3750	Macromolecules	HCAPLUS
Sotzing, G	2002	35	7281	Macromolecules	HCAPLUS
Sotzing, G	2003	88	268	Polym Mater Sci Eng	HCAPLUS
Sotzing, G	1997	84	199	Synth Met	HCAPLUS
Staes, E	1999		65	Electroanalysis	HCAPLUS
Swann, M	1993	55	281	Synth Met	HCAPLUS
Tachibana, M	2002	106	3549	J Phys Chem B	HCAPLUS
Takimiya, K	2002	75	1795	Bull Chem Soc Jpn	HCAPLUS
Taliani, C	1989	28	C507	Synth Met	HCAPLUS
Tanaka, S	1995	69	599	Synth Met	HCAPLUS
Tanaka, S	1997	84	229	Synth Met	HCAPLUS
Thomas, C	1999	735	367	Semiconducting polym	HCAPLUS
Toussaint, J	1995	69	637	Synth Met	HCAPLUS
Tsuda, A	2002	14	75	Adv Mater	HCAPLUS
van Asselt, R	1996	34	1553		HCAPLUS
van Asselt, R	11995	74	165	Synth Met	HCAPLUS
Vangeneugden, D		49	1687	Acta Polym	HCAPLUS
Vangeneugden, D		101	120	Synth Met	HCAPLUS

Verlhac, P	1998 95	1274	J Chim Phys	HCAPLUS
Wang, X	2004 85	5081	Appl Phys Lett	HCAPLUS
Wudl, F	1984 49	3382	J Org Chem	HCAPLUS
Yan, W	2002 13	1988	Chin Chem Lett	HCAPLUS
Yan, W	2001 19	499	Chin J Polym Sci	HCAPLUS
Zhang, F	2005 15	745	Adv Funct Mater	HCAPLUS
Zhang, Q	2004 39	6089	J Mater Sci	HCAPLUS
Zhang, Q	2004 146	169	Synth Met	HCAPLUS

L30 ANSWER 3 OF 33 HCAPLUS COPYRIGHT 2008 ACS on STN

AN 2006:941495 HCAPLUS Full-text

DN 145:344927

TI Polymerizable heteroarylamine compositions for forming electric conductors, and various kinds of electronic devices comprising same conductors

IN Shinohara, Yuji; Terao, Koichi

PA Seiko Epson Corp., Japan

SO Jpn. Kokai Tokkyo Koho, 62pp.

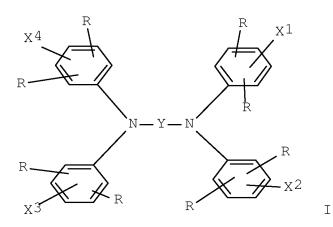
CODEN: JKXXAF

DT Patent

LA Japanese

FAN.CNT 1

T 1714 •	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
PI	JP 2006241267	A	20060914	JP 2005-57129	200503 02
PRAI GT	JP 2005-57129		20050302		0.2



```
The compns. contain (meth)acryloyloxyalkyl-bearing heteroarylamines I
AB
     [X1-4 = H2C:C(Z)CO2(CH2)n; Z = H, Me; n = 2-8; R = H, Me, Et; Y =
     group bearing (substituted) heterocycle], and urethane (meth)acrylate
     crosslinking agents. Elec. conductors formed by polymerizing the
     above heteroarylamines (with the crosslinking agents) are also
     claimed. Also claimed are various kinds of electronic devices
     comprising elec. (semi)conductors made from the compns., including
     electroluminescent devices, photoelec. conversion devices, elec.
     switches, and thin-film transistors. The (semi)conductors show good
     carrier-transport performance.
ΙΤ
     909421-16-5P 909421-19-8P 909421-20-1P
     909421-21-2P
     RL: DEV (Device component use); IMF (Industrial manufacture); TEM
     (Technical or engineered material use); PREP (Preparation); USES
     (Uses)
        (elec. conductor; polymerizable
        (meth)acryloyloxyalkyl-containing heteroarylamine composition for
forming
        elec. conductor of electronic device)
RN
     909421-16-5 HCAPLUS
CN
     2-Propenoic acid, 1,1'-bibenzo[c]thiophene-3,3'-
     diylbis[nitrilobis(4,1-phenylene-6,1-hexanediyl)] ester, polymer
     with \alpha-[[[methyl-3-[[[2-[(1-oxo-2-
     propenyl)oxy]ethoxy]carbonyl]amino]phenyl]amino]carbonyl]-\omega-
     [[[methyl-3-[[2-[(1-oxo-2-
     propenyl)oxy]ethoxy]carbonyl]amino]phenyl]amino]carbonyl]oxy]poly[ox
     y(methyl-1,2-ethanediyl)| (9CI) (CA INDEX NAME)
     CM
          1
     CRN 878028-09-2
     CMF C76 H84 N2 O8 S2
```

PAGE 1-A

PAGE 1-B

PAGE 2-A

CM 2

CRN 61420-45-9

CMF (C3 H6 O)n C28 H30 N4 O11

CCI IDS, PMS

PAGE 1-A
$$H_{2}C = CH - C - O - CH_{2} - CH_{2} - O - C - NH$$

$$2 \quad (D1-Me)$$

PAGE 1-B

RN 909421-19-8 HCAPLUS

CN 2-Propenoic acid, 1,1'-bibenzo[c]thiophene-3,3'-diylbis[nitrilobis(4,1-phenylene-2,1-ethanediyl)] ester, polymer with α -[[[methyl-3-[[[2-[(1-oxo-2-propenyl)oxy]ethoxy]carbonyl]amino]phenyl]amino]carbonyl]- ω -

[[[methyl-3-[[2-[(1-oxo-2propenyl)oxy]ethoxy]carbonyl]amino]phenyl]amino]carbonyl]oxy]poly[ox
y(methyl-1,2-ethanediyl)] (9CI) (CA INDEX NAME)

CM 1

CRN 878028-10-5 CMF C60 H52 N2 O8 S2

PAGE 1-A

$$CH_2-CH_2-O-C-CH=CH_2$$
 $CH_2-CH_2-O-C-CH=CH_2$
 $CH_2-CH_2-O-C-CH=CH_2$
 $CH_2-CH_2-O-C-CH=CH_2$

PAGE 1-B

— СН<u>—</u> СН2

PAGE 2-A

CM 2

CRN 61420-45-9

CMF (C3 H6 O)n C28 H30 N4 O11

CCI IDS, PMS

PAGE 1-A
$$H_2C = CH - C - O - CH_2 - CH_2 - O - C - NH$$

$$2 \quad (D1-Me)$$

PAGE 1-B

$$-(C3H6)$$
 $-\frac{1}{n}$ 0 $-\frac{0}{C}$ NH $-\frac{0}{C}$ -0 $-CH_2$ $-CH_2$ $-CH_2$ $-CH_2$ $-CH_2$

RN 909421-20-1 HCAPLUS
2-Propenoic acid, 1,1'-bibenzo[c]thiophene-3,3'-diylbis[nitrilobis(4,1-phenylene-8,1-octanediyl)] ester, polymer with α -[[[methyl-3-[[[2-[(1-oxo-2-propenyl)oxy]ethoxy]carbonyl]amino]phenyl]amino]carbonyl]- ω -[[[[methyl-3-[[[2-[(1-oxo-2-propenyl)oxy]ethoxy]carbonyl]amino]phenyl]amino]carbonyl]oxy]poly[oxy(methyl-1,2-ethanediyl)] (9CI) (CA INDEX NAME)

CM 1

CRN 878028-11-6 CMF C84 H100 N2 O8 S2

PAGE 1-A

PAGE 1-B

PAGE 2-A

CM 2

CRN 61420-45-9

CMF (C3 H6 O)n C28 H30 N4 O11

CCI IDS, PMS

PAGE 1-A
$$H_{2}C = CH - C - O - CH_{2} - CH_{2} - O - C - NH$$

$$2 \quad (D1-Me)$$

PAGE 1-B

RN 909421-21-2 HCAPLUS

CN 2-Propenoic acid, 1,1'-bibenzo[c]thiophene-3,3'-diylbis[[[4-[6-[(1-oxo-2-propenyl)oxy]hexyl]phenyl]imino]-4,1-phenylene-8,1-octanediyl] ester, polymer with α -[[[methyl-3-[[[2-[(1-oxo-2-propenyl)oxy]ethoxy]carbonyl]amino]phenyl]amino]carbonyl]- ω -

[[[methyl-3-[[2-[(1-oxo-2propenyl)oxy]ethoxy]carbonyl]amino]phenyl]amino]carbonyl]oxy]poly[ox
y(methyl-1,2-ethanediyl)] (9CI) (CA INDEX NAME)

CM 1

CRN 878028-12-7 CMF C80 H92 N2 O8 S2

> PAGE 1-A O

$$(CH_2)_{6-0-C-CH} = CH_2$$
 $(CH_2)_{6-0-C-CH} = CH_2$
 $(CH_2)_{8-0-C-CH} = CH_2$
 $(CH_2)_{8-0-C-CH} = CH_2$

PAGE 1-B

—СН2

PAGE 2-A

CM 2

CRN 61420-45-9

CMF (C3 H6 O)n C28 H30 N4 O11

CCI IDS, PMS

2 (D1—Me)

PAGE 1-B

CC 73-11 (Optical, Electron, and Mass Spectroscopy and Other Related Properties)

Section cross-reference(s): 27, 28, 38, 74, 76

IT 909421-09-6P 909421-10-9P 909421-11-0P 909421-12-1P

909421-13-2P 909421-14-3P 909421-15-4P 909421-16-5P

909421-17-6P 909421-18-7P 909421-19-8P

909421-20-1P 909421-21-2P 909421-22-3P

909421-23-4P 909421-24-5P

RL: DEV (Device component use); IMF (Industrial manufacture); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses)

(elec. conductor; polymerizable

(meth)acryloyloxyalkyl-containing heteroarylamine composition for forming

elec. conductor of electronic device)

L30 ANSWER 4 OF 33 HCAPLUS COPYRIGHT 2008 ACS on STN

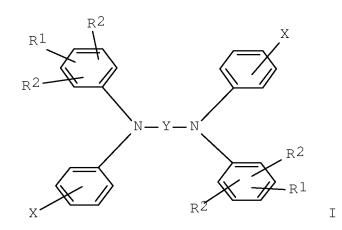
AN 2006:941451 HCAPLUS Full-text

DN 145:344926

- TI Polymerizable heteroarylamine compositions for forming electric conductors, and various kinds of electronic devices comprising same conductors
- IN Shinohara, Yuji; Terao, Koichi
- PA Seiko Epson Corp., Japan
- SO Jpn. Kokai Tokkyo Koho, 58pp. CODEN: JKXXAF

DT Patent LA Japanese FAN.CNT 1

T 2114 •	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
ΡI	 JP 2006241266	A	20060914	JP 2005-57127	200503
PRAI GI	JP 2005-57127		20050302		02



The compns. contain (meth)acryloyloxyalkyl-bearing heteroarylamines I [R1 = straight-chain C2-8 alkyl; R2 = H, Me, Et; X = H2C:C(Z)CO2(CH2)n; Z = H, Me; n = 2-8; Z = H, Me; Y = group bearing (substituted) heterocycle], and epoxy (meth)acrylate crosslinking agents. Elec. conductors formed by polymerizing the above heteroarylamines (with the crosslinking agents) are also claimed. Also claimed are various kinds of electronic devices comprising elec. (semi)conductors made from the compns., including electroluminescent devices, photoelec. conversion devices, elec. switches, and thin-film transistors. The (semi)conductors show good carrier-transport performance.

IT 909529-11-9P 909529-14-2P 909529-15-3P
 RL: DEV (Device component use); IMF (Industrial manufacture); TEM
 (Technical or engineered material use); PREP (Preparation); USES
 (Uses)

(elec. conductor; polymerizable

(meth)acryloyloxyalkyl-containing heteroarylamine composition for
forming

elec. conductor of electronic device)

RN 909529-11-9 HCAPLUS

CN 2-Propenoic acid, [1,1'-bibenzo[c]thiophene]-3,3'-diylbis[[(4-hexylphenyl)imino]-4,1-phenylene-6,1-hexanediyl] ester, polymer with (chloromethyl)oxirane polymer with

4,4'-(1-methylethylidene)bis[phenol] di-2-propenoate (9CI) (CA INDEX NAME)

CM 1

CRN 903577-16-2

CMF C70 H80 N2 O4 S2

PAGE 2-A

CMF (C15 H16 O2 . C3 H5 C1 O)x . 2 C3 H4 O2

CM 3

CRN 79-10-7 CMF C3 H4 O2

CM 4

CRN 25068-38-6

CMF (C15 H16 O2 . C3 H5 Cl O)x

CCI PMS

CM 5

CRN 106-89-8 CMF C3 H5 Cl O

CM 6

CRN 80-05-7 CMF C15 H16 O2

RN 909529-14-2 HCAPLUS

CN 2-Propenoic acid, [1,1'-bibenzo[c]thiophene]-3,3'-diylbis[[(4-ethylphenyl)imino]-4,1-phenylene-2,1-ethanediyl] ester, polymer with (chloromethyl)oxirane polymer with 4,4'-(1-methylethylidene)bis[phenol] di-2-propenoate (9CI) (CA INDEX NAME)

CM 1

CRN 903577-17-3 CMF C54 H48 N2 O4 S2

PAGE 1-A

Et
$$CH_2-CH_2-O-C-CH=CH_2$$

CM 2

CRN 53814-24-7

CMF (C15 H16 O2 . C3 H5 C1 O)x . 2 C3 H4 O2

CM 3

CRN 79-10-7

CMF C3 H4 O2

CM 4

CRN 25068-38-6

CMF (C15 H16 O2 . C3 H5 C1 O)x

CCI PMS

CM 5

CRN 106-89-8 CMF C3 H5 Cl O

CM 6

CRN 80-05-7 CMF C15 H16 O2

RN 909529-15-3 HCAPLUS

CN 2-Propenoic acid, [1,1'-bibenzo[c]thiophene]-3,3'-diylbis[[(4-

octylphenyl)imino]-4,1-phenylene-8,1-octanediyl] ester, polymer with (chloromethyl)oxirane polymer with

4,4'-(1-methylethylidene)bis[phenol] di-2-propenoate (9CI) (CA INDEX NAME)

CM 1

CRN 903577-18-4

CMF C78 H96 N2 O4 S2

PAGE 1-A

PAGE 2-A

CM 2

CRN 53814-24-7

CMF (C15 H16 O2 . C3 H5 Cl O)x . 2 C3 H4 O2

CM 3

CRN 79-10-7

CMF C3 H4 O2

CM 4

CRN 25068-38-6

CMF (C15 H16 O2 . C3 H5 Cl O) x

CCI PMS

CM 5

CRN 106-89-8

CMF C3 H5 Cl O

CM 6

CRN 80-05-7

CMF C15 H16 O2

CC 73-11 (Optical, Electron, and Mass Spectroscopy and Other Related Properties)

Section cross-reference(s): 2, 27, 38, 74, 76

IT 909529-05-1P 909529-06-2P 909529-07-3P 909529-08-4P 909529-09-5P 909529-10-8P 909529-11-9P 909529-12-0P

909529-13-1P 909529-14-2P 909529-15-3P

909529-16-4P 909529-17-5P 909529-18-6P

RL: DEV (Device component use); IMF (Industrial manufacture); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses)

(elec. conductor; polymerizable

(meth)acryloyloxyalkyl-containing heteroarylamine composition for forming

elec. conductor of electronic device)

L30 ANSWER 5 OF 33 HCAPLUS COPYRIGHT 2008 ACS on STN

AN 2006:941389 HCAPLUS Full-text

DN 145:344925

TI Polymerizable heteroarylamine compositions for forming electric conductors, and various kinds of electronic devices comprising same conductors

IN Terao, Koichi; Shinohara, Yuji

PA Seiko Epson Corp., Japan

SO Jpn. Kokai Tokkyo Koho, 70pp.

CODEN: JKXXAF

DT Patent

LA Japanese

FAN.CNT 1

I AIV•	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
ΡΙ	 JP 2006241295	A	20060914	JP 2005-58522	200503
PRAI	JP 2005-58522		20050303		03

GΙ

The compns. contain glycidyloxyalkyl-bearing heteroarylamines I [R1 = straight-chain C2-8 alkyl; R2 = H, Me, Et; X = Q; n = 2-8; Y = group bearing (substituted) heterocycle], and epoxy crosslinking agents. Elec. conductors formed by polymerizing the above heteroarylamines (with the crosslinking agents) are also claimed. Also claimed are various kinds of electronic devices comprising elec. (semi)conductors made from the compns., including electroluminescent devices, photoelec. conversion devices, elec. switches, and thin-film transistors. The (semi)conductors show good carrier-transport performance.

IT 909701-10-6P 909701-14-0P 909701-15-1P 909701-18-4P 909701-19-5P 909701-20-8P 909701-21-9P

RL: DEV (Device component use); IMF (Industrial manufacture); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses)

(elec. conductor; polymerizable

glycidyloxyalkyl-containing heteroarylamine composition for forming elec.

conductor of electronic device)

RN 909701-10-6 HCAPLUS

CN [1,1'-Bibenzo[c]thiophene]-3,3'-diamine,

N, N'-bis(4-hexylphenyl)-N, N'-bis[4-[6-(oxiranylmethoxy)hexyl]phenyl]-, polymer with 2,2'-[(1-methylethylidene)bis(4,1-phenyleneoxymethylene)]bis[oxirane] (9CI) (CA INDEX NAME)

CM 1

CRN 900812-56-8 CMF C70 H84 N2 O4 S2

CRN 1675-54-3 CMF C21 H24 O4

RN 909701-14-0 HCAPLUS

CN [1,1'-Bibenzo[c]thiophene]-3,3'-diamine,
 N,N'-bis(4-ethylphenyl)-N,N'-bis[4-[2-(oxiranylmethoxy)ethyl]phenyl] , polymer with 2,2'-[(1-methylethylidene)bis(4,1 phenyleneoxymethylene)]bis[oxirane] (9CI) (CA INDEX NAME)

CM 1

CRN 900812-57-9 CMF C54 H52 N2 O4 S2

CRN 1675-54-3 CMF C21 H24 O4

CM 1

CRN 900812-58-0 CMF C78 H100 N2 O4 S2

CRN 1675-54-3 CMF C21 H24 O4

RN 909701-18-4 HCAPLUS
CN 1,2-Cyclohexanedioctanoic acid, 4-hexyl-3-methylene-,
 bis(oxiranylmethyl) ester, polymer with
 N,N'-bis(4-hexylphenyl)-N,N'-bis[4-[6 (oxiranylmethoxy)hexyl]phenyl][1,1'-bibenzo[c]thiophene]-3,3'-

CM 1

CRN 900812-56-8 CMF C70 H84 N2 O4 S2

diamine (9CI) (CA INDEX NAME)

CRN 887651-88-9 CMF C35 H60 O6

RN 909701-19-5 HCAPLUS

CN [1,1'-Bibenzo[c]thiophene]-3,3'-diamine,
N,N'-bis(4-hexylphenyl)-N,N'-bis[4-[6-(oxiranylmethoxy)hexyl]phenyl], polymer with 3,3'-(1,3-dioxane-2,5-diyl)bis[7oxabicyclo[4.1.0]heptane] (9CI) (CA INDEX NAME)

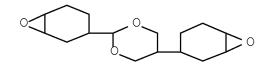
CM 1

CRN 900812-56-8

CMF C70 H84 N2 O4 S2

CM 2

CRN 39507-71-6 CMF C16 H24 O4



RN 909701-20-8 HCAPLUS

CN 2-Propenoic acid, oxiranylmethyl ester, polymer with N,N'-bis(4-hexylphenyl)-N,N'-bis[4-[6-(oxiranylmethoxy)hexyl]phenyl][1,1'-bibenzo[c]thiophene]-3,3'-diamine (9CI) (CA INDEX NAME)

CM 1

CRN 900812-56-8 CMF C70 H84 N2 O4 S2

CRN 106-90-1 CMF C6 H8 O3

RN 909701-21-9 HCAPLUS

CN [1,1'-Bibenzo[c]thiophene]-3,3'-diamine,
N,N'-bis(4-hexylphenyl)-N,N'-bis[4-[6-(oxiranylmethoxy)hexyl]phenyl], polymer with N,N'-(methylenedi-4,1-phenylene)bis[N(oxiranylmethyl)oxiranemethanamine] (9CI) (CA INDEX NAME)

CM 1

CRN 900812-56-8 CMF C70 H84 N2 O4 S2

CRN 28768-32-3 CMF C25 H30 N2 O4

$$\begin{array}{c} \begin{array}{c} \begin{array}{c} \\ \\ \\ \end{array} \end{array} \begin{array}{c} \\ \\ \\ \end{array} \begin{array}{c} \\ \\ \end{array} \begin{array}{c} \\ \\ \end{array} \begin{array}{c} \\ \\ \end{array} \begin{array}{c} \\ \\ \\ \end{array} \begin{array}{c} \\ \\ \end{array} \begin{array}{c} \\ \\ \\ \end{array} \begin{array}{c} \\ \\ \\ \end{array} \begin{array}{c} \\ \\ \end{array} \begin{array}{c} \\ \\ \\ \end{array} \begin{array}{c} \\ \\ \\ \end{array} \begin{array}{c}$$

- CC 73-11 (Optical, Electron, and Mass Spectroscopy and Other Related Properties)
 - Section cross-reference(s): 27, 28, 38, 74, 76
- 9016-83-5DP, cresol-formaldehyde copolymer glycidyl ethers, reaction products with heteroarylamine derivs. 878200-06-7DP, polymers with glycidyl-bearing poly(arylenealkenylenes) 878200-06-7DP, reaction products with epoxy derivs. 887651-96-9DP, reaction products with heteroarylamine derivs. 900812-55-7DP, polymers with

L30 AN

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ΙN PA

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PΙ

GΙ

```
glycidyl-bearing poly(arylenealkenylenes) 900812-55-7DP, reaction
    products with epoxy derivs. 900812-56-8DP, reaction products with
                   909701-04-8P 909701-05-9P 909701-06-0P
    epoxy derivs,
    909701-07-1P 909701-08-2P 909701-09-3P 909701-10-6P
    909701-11-7P 909701-12-8P 909701-13-9P 909701-14-0P
    909701-15-1P 909701-16-2P
                                 909701-17-3P
    909701-18-4P 909701-19-5P 909701-20-8P
    909701-21-9P 909701-22-0P 909701-23-1P 909701-24-2P
    909701-25-3P 909701-26-4P 909701-27-5P 909701-28-6P
    909701-30-0P 909701-31-1P 909701-32-2P 909701-33-3P
    909701-34-4P 909701-35-5P 909701-36-6P 909701-37-7P
    909701-38-8P 909701-39-9P 909701-40-2P 909701-41-3P
    909701-42-4P 909701-43-5P 909701-44-6P 909701-45-7P
    909701-46-8P 909701-47-9P 909701-48-0P 909705-48-2P
    909705-49-3P
    RL: DEV (Device component use); IMF (Industrial manufacture); TEM
     (Technical or engineered material use); PREP (Preparation); USES
     (Uses)
       (elec. conductor; polymerizable
       qlycidyloxyalkyl-containing heteroarylamine composition for
       conductor of electronic device)
    ANSWER 6 OF 33 HCAPLUS COPYRIGHT 2008 ACS on STN
    2006:941208 HCAPLUS Full-text
    145:324605
    Polymerizable heteroarylamine compositions for forming electric
    conductors, and various kinds of electronic devices comprising same
    Shinohara, Takashi; Terao, Koichi; Shinohara, Yuji
    Seiko Epson Corp., Japan
    Jpn. Kokai Tokkyo Koho, 65pp.
    CODEN: JKXXAF
    Patent
    Japanese
FAN.CNT 1
    PATENT NO.
                       KIND
                                        APPLICATION NO.
                                                               DATE
                              DATE
    _____
                       ____
    _____
    JP 2006241213
                       A
                             20060914 JP 2005-55435
                                                                200503
                                                                01
PRAI JP 2005-55435
                              20050301
```

The compns. contain vinyl-bearing heteroarylamines I [X1-4 = H2C:C(Z)-p-C6H4(CH2)mO(CH2)n; Z = H, Me, Et; m = 0-3; n = 3-8; R = H, Me, Et; Y = group bearing (substituted) heterocycle], and vinyl-bearing crosslinking agents. Elec. conductors formed by polymerizing the above heteroarylamines (with vinyl comonomers) are also claimed. Also claimed are various kinds of electronic devices comprising elec. (semi)conductors made from the compns., including electroluminescent devices, photoelec. conversion devices, elec. switches, and thin-film transistors. The (semi)conductors show good carrier-transport performance.

IT 909422-62-4P 909422-64-6P 909422-66-8P 909422-68-0P 909422-70-4P 909422-72-6P 909422-73-7P

RL: DEV (Device component use); IMF (Industrial manufacture); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses)

(elec. conductor; polymerizable

vinyl-containing heteroarylamine composition for forming elec. conductor

of electronic device)

RN 909422-62-4 HCAPLUS

CN [1,1'-Bibenzo[c]thiophene]-3,3'-diamine, N,N,N',N'-tetrakis[4-[6-[(4-ethenylphenyl)methoxy]hexyl]phenyl]-, polymer with α -(1-oxo-2-propenyl)- ω -[(1-oxo-2-propenyl)oxy]poly(oxy-1,2-ethanediyl) (9CI) (CA INDEX NAME)

CM 1

CRN 884540-95-8 CMF C100 H108 N2 O4 S2

PAGE 3-A

CM 2

CRN 26570-48-9

CMF (C2 H4 O)n C6 H6 O3

CCI PMS

$$H_2C = CH - CH_2 - CH$$

RN 909422-64-6 HCAPLUS

CN [1,1'-Bibenzo[c]thiophene]-3,3'-diamine, N,N,N',N'-tetrakis[4-[6-[(4-ethenylphenyl)methoxy]hexyl]phenyl]-, polymer with diethenylbenzene (9CI) (CA INDEX NAME)

CM 1

CRN 884540-95-8 CMF C100 H108 N2 O4 S2

PAGE 1-A

PAGE 3-A



CM 2

CRN 1321-74-0 CMF C10 H10 CCI IDS



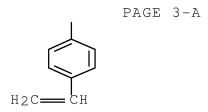
$$2 \Gamma D1 - CH = CH_2$$

RN 909422-66-8 HCAPLUS $[1,1'-Bibenzo[c]thiophene]-3,3'-diamine, \\ N,N,N',N'-tetrakis[4-[6-[2-(4-ethenylphenyl)ethoxy]hexyl]phenyl]-, \\ polymer with $\alpha-(1-oxo-2-propenyl)-\omega-[(1-oxo-2-propenyl)oxy]poly(oxy-1,2-ethanediyl) (9CI) (CA INDEX NAME)$

CM 1

CRN 884540-96-9 CMF C104 H116 N2 O4 S2

PAGE 1-A



CMF (C2 H4 O)n C6 H6 O3

CCI PMS

$$\label{eq:h2C} \texttt{H2C} = \texttt{CH} - \overset{\circlearrowleft}{\texttt{C}} - \overset{\circlearrowleft}{\texttt{C}} - \texttt{CH2} - \texttt{CH2} - \texttt{CH2} - \texttt{CH2} - \texttt{CH2} - \texttt{CH2}$$

RN 909422-68-0 HCAPLUS

CN [1,1'-Bibenzo[c]thiophene]-3,3'-diamine, N,N,N',N'-tetrakis[4-[3-[(4-ethenylphenyl)methoxy]propyl]phenyl]-, polymer with α -(1-oxo-2-propenyl)- ω -[(1-oxo-2-propenyl)oxy]poly(oxy-1,2-ethanediyl) (9CI) (CA INDEX NAME)

CM 1

CRN 884540-97-0 CMF C88 H84 N2 O4 S2

PAGE 1-A

PAGE 3-A



CM 2

CRN 26570-48-9

CMF (C2 H4 O)n C6 H6 O3

CCI PMS

$$\label{eq:h2C} \texttt{H2C} = \texttt{CH} - \overset{\circlearrowleft}{\texttt{C}} - \overset{\circlearrowleft}{\texttt{C}} - \texttt{CH2} - \texttt{CH2} - \texttt{CH2} - \overset{\circlearrowleft}{\texttt{CH2}} - \texttt{CH2} - \texttt{CH2}$$

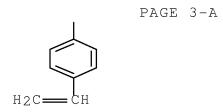
RN 909422-70-4 HCAPLUS

CN [1,1'-Bibenzo[c]thiophene]-3,3'-diamine, N,N,N',N'-tetrakis[4-[3-[3-(4-ethenylphenyl)propoxy]propyl]phenyl]-, polymer with α -(1-oxo-2-propenyl)- ω -[(1-oxo-2-propenyl)oxy]poly(oxy-1,2-ethanediyl) (9CI) (CA INDEX NAME)

CM 1

CRN 884540-98-1

CMF C96 H100 N2 O4 S2



CMF (C2 H4 O)n C6 H6 O3

CCI PMS

$$\label{eq:h2C} \texttt{H2C} = \texttt{CH} - \overset{\circlearrowleft}{\texttt{C}} - \overset{\circlearrowleft}{\texttt{C}} - \texttt{CH2} - \texttt{CH2} - \texttt{CH2} - \texttt{CH2} - \texttt{CH2} - \texttt{CH2}$$

RN 909422-72-6 HCAPLUS

CN [1,1'-Bibenzo[c]thiophene]-3,3'-diamine, N,N,N',N'-tetrakis[4-[8-[(4-ethenylphenyl)methoxy]octyl]phenyl]-, polymer with α -(1-oxo-2-propenyl)- ω -[(1-oxo-2-propenyl)oxy]poly(oxy-1,2-ethanediyl) (9CI) (CA INDEX NAME)

CM 1

CRN 884540-99-2 CMF C108 H124 N2 O4 S2

PAGE 1-A

PAGE 3-A



CM 2

CRN 26570-48-9

CMF (C2 H4 O)n C6 H6 O3

CCI PMS

$$\label{eq:h2C} \texttt{H2C} = \texttt{CH} - \overset{\circlearrowleft}{\texttt{C}} - \underbrace{\texttt{C}} - \texttt{O} - \texttt{CH2} - \texttt{CH2} - \underbrace{\texttt{CH2}}_{\texttt{n}} - \texttt{O} - \overset{\circlearrowleft}{\texttt{C}} - \texttt{CH} = \texttt{CH2}$$

RN 909422-73-7 HCAPLUS

CN [1,1'-Bibenzo[c]thiophene]-3,3'-diamine,

N, N'-bis[4-[6-[(4-ethenylphenyl)methoxy]hexyl]phenyl]-N, N'-bis[4-[8-

[(4-ethenylphenyl)methoxy]octyl]phenyl]-, polymer with

 α -(1-oxo-2-propenyl)- ω -[(1-oxo-2-propenyl)oxy]poly(oxy-

1,2-ethanediyl) (9CI) (CA INDEX NAME)

CM 1

CRN 884541-00-8

CMF C104 H116 N2 O4 S2

PAGE 3-A

CM 2

CRN 26570-48-9

CMF (C2 H4 O)n C6 H6 O3

CCI PMS

$$H_2C = CH - CH_2 - CH$$

CC 73-11 (Optical, Electron, and Mass Spectroscopy and Other Related Properties)
Section cross-reference(s): 27, 28, 38, 74, 76

```
ΙT
     909422-38-4P
                   909422-41-9P
                                909422-43-1P 909422-45-3P
     909422-46-4P 909422-48-6P 909422-50-0P 909422-52-2P
     909422-54-4P 909422-56-6P
                                 909422-58-8P 909422-60-2P
     909422-62-4P 909422-64-6P 909422-66-8P
     909422-68-0P 909422-70-4P 909422-72-6P
     909422-73-7P 909422-75-9P
                                909422-77-1P 909422-79-3P
     RL: DEV (Device component use); IMF (Industrial manufacture); TEM
     (Technical or engineered material use); PREP (Preparation); USES
        (elec. conductor; polymerizable
       vinyl-containing heteroarylamine composition for forming elec.
conductor
        of electronic device)
L30
    ANSWER 7 OF 33 HCAPLUS COPYRIGHT 2008 ACS on STN
ΑN
    2006:792922 HCAPLUS Full-text
DN
    145:239247
    Electrically conductive conjugated polymer fiber, preparation and
ΤI
    use thereof
    Mather, Patrick T.; Sotzing, Gregory A.
IN
PA
    University of Connecticut, USA
    PCT Int. Appl., 73pp.
SO
    CODEN: PIXXD2
DT
    Patent
LA
    English
FAN.CNT 1
                       KIND DATE
    PATENT NO.
                                      APPLICATION NO.
                                                                  DATE
                       ____
PΙ
    WO 2006084088
                        A1 20060810
                                          WO 2006-US3764
                                                                  200601
                                                                  31
            AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BW, BY, BZ, CA,
            CH, CN, CO, CR, CU, CZ, DE, DK, DM, DZ, EC, EE, EG, ES, FI,
            GB, GD, GE, GH, GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KM,
            KN, KP, KR, KZ, LC, LK, LR, LS, LT, LU, LV, LY, MA, MD, MG,
            MK, MN, MW, MX, MZ, NA, NG, NI, NO, NZ, OM, PG, PH, PL, PT,
            RO, RU, SC, SD, SE, SG, SK, SL, SM, SY, TJ, TM, TN, TR, TT,
            TZ, UA, UG, US, UZ, VC, VN, YU, ZA, ZM, ZW
        RW: AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HU,
             IE, IS, IT, LT, LU, LV, MC, NL, PL, PT, RO, SE, SI, SK, TR,
            BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, ML, MR, NE, SN, TD,
            TG, BW, GH, GM, KE, LS, MW, MZ, NA, SD, SL, SZ, TZ, UG, ZM,
            ZW, AM, AZ, BY, KG, KZ, MD, RU, TJ, TM
                        A1 20070426 US 2006-343552
    US 20070089845
                                                                  200601
                                                                  31
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PRAI US 2005-648588P P 20050131

Described are conjugated polymer fibers prepared by the method comprising electrospinning a solution of intrinsically conductive polymer, intrinsically conductive polymer precursor, or a combination thereof to form a fiber; and crosslinking the intrinsically conductive polymer, intrinsically conductive polymer precursor, or a combination thereof. The conjugated polymer fibers, which can be nanofibers, may be formed into structures in the form of a nonwoven mat or a mat comprising aligned conjugated polymer fibers, or formed into an article such as an electrochromic window or display device. A method of preparing a micropattern of conjugated polymer fiber is further disclosed.

IT 91201-85-3, Poly(isothianaphthene)

RL: PEP (Physical, engineering or chemical process); PYP (Physical process); TEM (Technical or engineered material use); PROC (Process); USES (Uses)

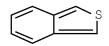
(fibers; elec. conductive conjugated polymer electrospun nanofibers for elec. devices)

RN 91201-85-3 HCAPLUS

CN Benzo[c]thiophene, homopolymer (CA INDEX NAME)

CM 1

CRN 270-82-6 CMF C8 H6 S



CC 76-2 (Electric Phenomena)

25038-69-1, Poly(phenylacetylene) 25067-58-7, Polyacetylene ΙT 25086-73-1, Poly(benzofuran) 25233-30-1, Polyaniline 25233-34-5, Polythiophene 26009-24-5, Poly(p-phenylenevinylene) 30281-16-4 30604-81-0, Polypyrrole 51555-21-6, Polycarbazole 82451-55-6, 82451-56-7, Poly(azulene) 87431-36-5, Poly(indole) Poly(dibenzothiophene) 88995-53-3, trans-1,2-Di(2-thienyl)ethylene homopolymer 91201-85-3, Poly(isothianaphthene) 94479-77-3, Poly(thieno[3,2-b]thiophene) 95270-88-5, Polyfluorene 98507-51-8, Poly(dithieno[3,2-b:2',3'-d]thiophene) 98845-54-6, Poly(4H-thieno[3,2-b]pyrrole) 102250-99-7, Polydibenzofuran 111519-23-4, Poly(1,4-dihydro-pyrrolo[3,2-b]pyrrole) 113151-41-0, trans-1,2-Di(2-furanyl)ethylene homopolymer 120496-10-8,

```
Poly(1,7-dihydro-thieno[3,2-b:4,5-b']dipyrrole)
                                                      125541-34-6,
     Poly(2',3'-pyrazinothiophene)
                                   126213-51-2,
     Poly(3,4-ethylenedioxythiophene)
                                       130777-75-2,
     Poly(thieno[3,4-b]pyridine)
                                  155861-78-2,
                                        157312-38-4, Poly(2,2'-biindole)
     Poly(3,4-propylenedioxythiophene)
     158962-93-7, Poly(3,4-ethylenedithiathiophene)
                                                     162899-00-5,
     Poly(1,2-trans-(3,4-ethylenedioxy-2-thienyl)vinylene) 183889-83-0,
     trans-1, 2-Di(2-pyrrolyl)ethylene homopolymer
                                                   259737-85-4,
     Poly(3,4-ethylenedioxypyrrole)
                                     259737-87-6,
     Poly(3,4-propylenedioxypyrrole)
                                      800625-03-0,
                              800625-19-8, Poly(4H-furo[3,2-b]pyrrole)
     Poly(thieno[3,2-b]furan)
     800625-26-7, Poly(4H-furo[3,2-b]furan)
                                             800625-74-5,
     Poly(thieno[3,2-b:4,5-b']difuran)
                                        800625-89-2,
     Poly(dithieno[3,2-b:2',3'-d]furan)
                                         800625-97-2,
     Poly(1,7-dihydro-furo[3,2-b:4,5-b']dipyrrole) 800626-07-7,
     Poly(4,7-dihydro-1H-dipyrrolo[3,2-b:2',3'-d]pyrrole)
                                                           800626-56-6,
     Poly(1,2-trans-(3,4-ethylenedioxy-2-furanyl)vinylene)
                                                            800626-65-7,
    Poly(1,2-trans-(3,4-ethylenedioxy-2-pyrrolyl)vinylene)
    RL: PEP (Physical, engineering or chemical process); PYP (Physical
     process); TEM (Technical or engineered material use); PROC
     (Process); USES (Uses)
        (fibers; elec. conductive conjugated
       polymer electrospun nanofibers for elec. devices)
RETABLE
                      |Year | VOL | PG | Referenced Work
   Referenced Author
Referenced
                       |(RPY)|(RVL)|(RPG)|
                                                (RWK)
         (RAU)
                                                              | File
_____+
                                         |WO 0151690 A
Ko
                      |2001 |
Macdiarmid, A
                      |2001 |40
                                  |2581 | ANGEWANDTE CHEMIE, I | HCAPLUS
Maynor, B
                      |2002 |124
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                                         | JOURNAL OF THE AMERI| HCAPLUS
Okuzaki, H
                      |2005 |
                                         |US 2005287366 A1
                                  | HCAPLUS
Senecal, K
                      |2001 |
                                         |US 2001045547 A1
                      |2004 |
Sotzing, G
                                         |US 2004242792 A1
Sotzing, G
                      |1994 |
                                  371
                                         | POLYMERIC MATERIALS
                      12005 | 46
                                  1513
Sung-Yeon, J
                                         | POLYMER PREPRINTS
The Dow Chemical Compan | 1994 |
                                         |EP 0577406 A
                                                              | HCAPLUS
                                  L30
    ANSWER 8 OF 33
                   HCAPLUS COPYRIGHT 2008 ACS on STN
ΑN
     2006:760104 HCAPLUS Full-text
     145:198535
DN
ΤI
    Polymerizable heteroarylamine compositions for forming electric
     conductors, and various kinds of electronic devices comprising same
     conductors
     Shinohara, Yuji; Terao, Koichi
ΙN
PA
     Seiko Epson Corp., Japan
```

10593498

SO Jpn. Kokai Tokkyo Koho, 51 pp.

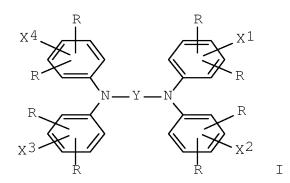
CODEN: JKXXAF

DT Patent

LA Japanese

FAN.CNT 1

T TIV • (PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
	FAIENI NO.		DAIL	AFFLICATION NO.	DAIL
ΡI	JP 2006199910	A	20060803	JP 2005-123191	200504
					21
	JP 2004-367212	A	20041220		
OS GT	MARPAT 145:198535				



The compns. contain (meth)acryloyl-bearing heteroarylamines I [X1-4 = CH2:C(Z)CO2(CH2)n; Z = H, Me; n = 2-8; R = H, Me, Et; Y = group bearing (substituted) heterocycle]. Also claimed are various kinds of electronic devices comprising elec. (semi)conductors made from the compns., including electroluminescent devices, photoelec. conversion devices, elec. switches, and thin-film transistors. The (semi)conductors show good carrier-transport performance.

IT 903579-23-7P 903579-24-8P 903579-25-9P 903579-26-0P

RL: DEV (Device component use); IMF (Industrial manufacture); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses)

(elec. conductor; polymerizable

(meth)acryloyl-containing heteroarylamine composition for forming elec.

conductor of electronic device)

RN 903579-23-7 HCAPLUS

CN 2-Propenoic acid, 1,1'-bibenzo[c]thiophene-3,3'-diylbis[nitrilobis(4,1-phenylene-6,1-hexanediyl)] ester, homopolymer (9CI) (CA INDEX NAME)

CM 1

CRN 878028-09-2

CMF C76 H84 N2 O8 S2

PAGE 1-A

$$H_2C = CH - C - O - (CH_2)_6$$
 $CH_2)_6 - O - C - CH = CH_2$
 $CH_2)_6 - O - C - CH = CH_2$
 $CH_2)_6 - O - C - CH = CH_2$

PAGE 1-B

—CH2

$$H_{2}C = CH - C - O - (CH_{2}) 6$$

PAGE 2-A

RN 903579-24-8 HCAPLUS
CN 2-Propenoic acid, 1,1'-bibenzo[c]thiophene-3,3'diylbis[nitrilobis(4,1-phenylene-2,1-ethanediyl)] ester, homopolymer
(9CI) (CA INDEX NAME)

CM 1

CRN 878028-10-5 CMF C60 H52 N2 O8 S2

PAGE 1-A

$$CH_2-CH_2-O-C-CH=CH_2$$
 $CH_2-CH_2-O-C-CH=CH_2$
 $CH_2-CH_2-O-C-CH=CH_2$
 $CH_2-CH_2-O-C-CH=CH_2$
 $CH_2-CH_2-O-C-CH=CH_2$

PAGE 1-B

PAGE 2-A

RN 903579-25-9 HCAPLUS

CN 2-Propenoic acid, 1,1'-bibenzo[c]thiophene-3,3'-diylbis[nitrilobis(4,1-phenylene-8,1-octanediyl)] ester, homopolymer (9CI) (CA INDEX NAME)

CM 1

CRN 878028-11-6

CMF C84 H100 N2 O8 S2

PAGE 1-A

PAGE 1-B

— CH2

PAGE 2-A

RN 903579-26-0 HCAPLUS
CN 2-Propenoic acid, 1,1'-bibenzo[c]thiophene-3,3'-diylbis[[[4-[6-[(1-oxo-2-propenyl)oxy]hexyl]phenyl]imino]-4,1-phenylene-8,1-octanediyl] ester, homopolymer (9CI) (CA INDEX NAME)

CM 1

CRN 878028-12-7 CMF C80 H92 N2 O8 S2

PAGE 1-A

$$H_2C = CH - CH_2 = CH$$

PAGE 1-B

PAGE 2-A

CC 73-11 (Optical, Electron, and Mass Spectroscopy and Other Related Properties)

Section cross-reference(s): 27, 28, 38, 74, 76

IT 903579-14-6P 903579-15-7P 903579-16-8P 903579-17-9P 903579-18-0P 903579-19-1P 903579-20-4P 903579-21-5P

903579-22-6P 903579-23-7P 903579-24-8P

903579-25-9P 903579-26-0P 903579-27-1P

903579-28-2P 903579-29-3P

RL: DEV (Device component use); IMF (Industrial manufacture); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses)

(elec. conductor; polymerizable

(meth)acryloyl-containing heteroarylamine composition for forming
elec.

conductor of electronic device)

L30 ANSWER 9 OF 33 HCAPLUS COPYRIGHT 2008 ACS on STN

AN 2006:760101 HCAPLUS Full-text

DN 145:198534

TI Polymerizable heteroarylamine compositions for forming electric conductors, and various kinds of electronic devices comprising same conductors

IN Shinohara, Yuji; Terao, Koichi

PA Seiko Epson Corp., Japan

SO Jpn. Kokai Tokkyo Koho, 52 pp. CODEN: JKXXAF

DT Patent

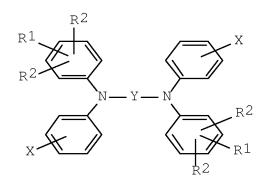
LA Japanese

FAN.CNT 1

	PATENT NO.	KIND DATE APPI		APPLICATION NO.	DATE
ΡI	JP 2006199909	А	20060803	JP 2005-123190	

200504 21

PRAI JP 2004-367211 A 20041220 OS MARPAT 145:198534 GI



The compns. contain (meth)acryloyl-bearing heteroarylamines I [R1 = C2-8 linear-chained alkyl; R2 = H, Me, Et; X = CH2:C(Z)CO2(CH2)n; Z = H, Me; n = 2-8; Y = (substituted) heterocycle-bearing group]. Also claimed are various kinds of electronic devices comprising elec. (semi)conductors made from the compns., including electroluminescent devices, photoelec. conversion devices, elec. switches, and thin-film transistors. The (semi)conductors show good carrier-transport performance.

IT 903577-35-5P 903577-36-6P 903577-37-7P

RL: DEV (Device component use); IMF (Industrial manufacture); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses)

(elec. conductor; polymerizable

Ι

(meth)acryloyl-containing heteroarylamine composition for forming elec.

conductor of electronic device)

RN 903577-35-5 HCAPLUS

CN 2-Propenoic acid, [1,1'-bibenzo[c]thiophene]-3,3'-diylbis[[(4-hexylphenyl)imino]-4,1-phenylene-6,1-hexanediyl] ester, homopolymer (9CI) (CA INDEX NAME)

CM 1

CRN 903577-16-2 CMF C70 H80 N2 O4 S2

PAGE 1-A

PAGE 2-A

RN 903577-36-6 HCAPLUS

CN 2-Propenoic acid, [1,1'-bibenzo[c]thiophene]-3,3'-diylbis[[(4-ethylphenyl)imino]-4,1-phenylene-2,1-ethanediyl] ester, homopolymer (9CI) (CA INDEX NAME)

CM 1

CRN 903577-17-3

CMF C54 H48 N2 O4 S2

PAGE 1-A

PAGE 2-A

903577-37-7 HCAPLUS

RN

CN 2-Propenoic acid, [1,1'-bibenzo[c]thiophene]-3,3'-diylbis[[(4-octylphenyl)imino]-4,1-phenylene-8,1-octanediyl] ester, homopolymer (9CI) (CA INDEX NAME)

CM 1

CRN 903577-18-4

CMF C78 H96 N2 O4 S2

PAGE 1-A

Me— (CH₂) 7
$$\sim$$
 CH— CH₂ \sim CH₂ \sim CH

PAGE 2-A

CC 73-11 (Optical, Electron, and Mass Spectroscopy and Other Related Properties)
Section cross-reference(s): 27, 28, 38, 74, 76

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    903577-25-3P
                   903577-27-5P
                                903577-28-6P 903577-29-7P
    903577-30-0P
                   903577-31-1P
                                  903577-32-2P 903577-33-3P
    903577-34-4P 903577-35-5P 903577-36-6P
    903577-37-7P 903577-38-8P
                                 903577-39-9P 903577-40-2P
    RL: DEV (Device component use); IMF (Industrial manufacture); TEM
     (Technical or engineered material use); PREP (Preparation); USES
     (Uses)
        (elec. conductor; polymerizable
        (meth)acryloyl-containing heteroarylamine composition for forming
elec.
       conductor of electronic device)
L30
    ANSWER 10 OF 33
                    HCAPLUS COPYRIGHT 2008 ACS on STN
AN
    2005:1049915 HCAPLUS Full-text
DN
    Crosslinked self-doping type electrically conducting polymer,
TΙ
    production process thereof, product coated with the polymer and
    electronic device
    Saida, Yoshihiro; Ohkubo, Takashi
ΙN
PA
    Showa Denko K. K., Japan
SO
    PCT Int. Appl., 107 pp.
    CODEN: PIXXD2
DT
    Patent
LA
    English
FAN.CNT 1
                       KIND DATE APPLICATION NO.
    PATENT NO.
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    WO 2005091309 A1 20050929 WO 2005-JP5996
PI
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            KZ, LC, LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX,
            MZ, NA, NI, NO, NZ, OM, PG, PH, PL, PT, RO, RU, SC, SD, SE,
            SG, SK, SL, SM, SY, TJ, TM, TN, TR, TT, TZ, UA, UG, US, UZ,
            VC, VN, YU, ZA, ZM, ZW
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            AM, AZ, BY, KG, KZ, MD, RU, TJ, TM, AT, BE, BG, CH, CY, CZ,
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            GN, GQ, GW, ML, MR, NE, SN, TD, TG
    JP 2006096974
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                        A1
                               20061206 EP 2005-721645
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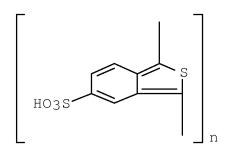
200503 23 AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HU, IE, IS, IT, LI, LT, LU, MC, NL, PL, PT, RO, SE, SI, SK, TR 20070321 CN 2005-80008929 CN 1934658 Α 200503 23 US 20070194285 20070823 US 2006-593498 Α1 200609 20 KR 2007008642 20070117 KR 2006-721655 Α 200610 18 KR 803699 20080220 В1 PRAI JP 2004-87370 20040324 Α Ρ US 2004-558555P 20040402 20040903 JP 2004-257435 Α US 2004-608873P Ρ 20040913 WO 2005-JP5996 W 20050323 AB The invention relates to a self-doping type elec. conducting polymer comprising an isothianaphthene or thiophene skeleton where the polymer chains are crosslinked preferably through a sulfone bond, as represented by formula (2) or (5) below, which is imparted with water resistance and solvent resistance; a production process thereof; an elec. conducting composition film obtained by coating a composition containing the self-doping type elec. conducting polymer on a substrate and heating it; a product coated using the composition; and an electronic device containing the self-doping type elec. conducting polymer: (wherein the symbols are as described in the specification). ΙT 181815-08-7D, crosslinked 188754-53-2D, Poly(5-sulfobenzo[c]thiophene-1,3-diyl), crosslinked RL: DEV (Device component use); USES (Uses) (crosslinked self-doping elec. conducting polymer for electronic device) 181815-08-7 HCAPLUS RN CN Benzo[c]thiophene-5-sulfonic acid, homopolymer (9CI) (CA INDEX

CM 1

NAME)

CRN 181815-07-6 CMF C8 H6 O3 S2

188754-53-2 HCAPLUS RN Poly(5-sulfobenzo[c]thiophene-1,3-diyl) (CA INDEX NAME) CN



IC

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ICM H01B001-12
    ICS C08G061-12
CC
    76-3 (Electric Phenomena)
    Section cross-reference(s): 38, 74
ΙT
    135899-67-1D, crosslinked 139439-92-2D, crosslinked
    181815-08-7D, crosslinked 188754-53-2D,
    Poly(5-sulfobenzo[c]thiophene-1,3-diyl), crosslinked
    RL: DEV (Device component use); USES (Uses)
      (crosslinked self-doping elec. conducting
      polymer for electronic device)
RETABLE
  Referenced Author | Year | VOL | PG | Referenced Work |
Referenced
                   |(RPY)|(RVL)|(RPG)|
                                         (RWK)
|1991 |015 |C-0896|PATENT ABSTRACTS OF |
Anon
                   Anon
                   |2001 |2000 |
                                   | PATENT ABSTRACTS OF |
Anon
Mitsubishi Rayon Co Ltd | 2001 |
                             |JP 2001098069 A
                                                     | HCAPLUS
Showa Denko Kabushiki K|1993 |
                                  |EP 0545417 A
                             - 1
                                                     | HCAPLUS
Showa Denko Kk
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                  |1998 | |
                                |JP 10168328 A
Showa Denko Kk
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ANSWER 11 OF 33 HCAPLUS COPYRIGHT 2008 ACS on STN
L30
AN
     2005:394777 HCAPLUS Full-text
DN
     142:412900
ΤI
    Durable highly conductive synthetic fabric construction containing
     electrical conductive polymers
    Levine, Mark; O'Connor, Joseph G.; Ditaranto, Frank; Toney, Crayton
IN
     Gregory; Luo, Shuiyuan
     Albany International Corp, USA
PA
SO
    U.S. Pat. Appl. Publ., 5 pp.
     CODEN: USXXCO
DT
    Patent
LA
    English
FAN.CNT 1
     PATENT NO.
                       KIND
                                                                  DATE
                               DATE
                                          APPLICATION NO.
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    US 20050095935
                        A1
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                                          US 2003-699997
                                                                  200311
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    AU 2003297917
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                               20040606
                                           AU 2003-297917
                                                                  200312
                                                                  12
     CA 2544634
                         Α1
                               20050526
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    WO 2005047576
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             SG, SK, SL, SY, TJ, TM, TN, TR, TT, TZ, UA, UG, UZ, VC, VN,
             YU, ZA, ZM, ZW
        RW: BW, GH, GM, KE, LS, MW, MZ, SD, SL, SZ, TZ, UG, ZM, ZW, AM,
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            AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC,
             PT, IE, SI, FI, RO, CY, TR, BG, CZ, EE, HU, SK
                             20061010 BR 2003-18565
    BR 2003018565
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                                                                  200312
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JP	2007521405	T	20070802	JP	2005-510670	200312
						12
RU	2335584	C2	20081010	RU	2006-113689	200312
IN	2006DN02323	A	20070713	IN	2006-DN2323	12
						200604 27
MX	2006PA04800	A	20060703	MX	2006-PA4800	200604
NO	2006002519	A	20060801	NΟ	2006-2519	28
110	2000002019	7.7	20000001	110	2000 2317	200606 01
PRAI US	2003-699997	A	20031103			0 1
WO	2003-US39623	W	20031212			

AB Title conductive fabric comprises a plurality of oriented polymeric filaments, wherein each filament includes elec. conductive polymer material incorporated as either a blend or a coating, the conductive fabric having static dissipation properties comparable to metal-based fabrics while being resistant to dents and creases. The fabric also has desirable phys. properties comparable to non-conductive synthetic fabrics.

IT 91201-85-3, Poly-isothianaphthene

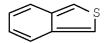
RL: TEM (Technical or engineered material use); USES (Uses) (filaments; durable highly conductive synthetic fabric construction containing elec. conductive polymers)

RN 91201-85-3 HCAPLUS

CN Benzo[c]thiophene, homopolymer (CA INDEX NAME)

CM 1

CRN 270-82-6 CMF C8 H6 S



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IC ICM B32B027-02
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INCL 442110000; X44-216.4; X42-829.97; X42-837.5; X42-837.8; X42-839.4; X42-840.7

CC 40-10 (Textiles and Fibers)

IT 25067-58-7, Polyacetylene 25190-62-9, Poly(1,4-phenylene) 25190-62-9D, Poly(1,4-phenylene), 2,5-alkoxy-substituted 25212-74-2, Poly(thio-1,4-phenylene) 25233-34-5, Polythiophene 26009-24-5, Poly(1,4-phenylene-1,2-ethenediyl) 26009-24-5D, Poly(1,4-phenylene-1,2-ethenediyl), alkoxy-substituted 30604-81-0, Polypyrrole 91201-85-3, Poly-isothianaphthene 104934-50-1, Poly(3-hexyl thiophene) 126213-51-2, Poly(ethylene dioxythiophene

RL: TEM (Technical or engineered material use); USES (Uses) (filaments; durable highly conductive synthetic fabric construction containing elec. conductive polymers)

- L30 ANSWER 12 OF 33 HCAPLUS COPYRIGHT 2008 ACS on STN
- AN 2005:259271 HCAPLUS Full-text

DN 142:282618

- TI Electrically conducting lubricating greases containing conducting polymers, especially for electric motors and bearing assemblies
- IN Kuo, Ming C.; Hoover, William R.; Akkala, Marc W.; Mehlhorn, William L.
- PA A.O. Smith Corporation, USA
- SO U.S. Pat. Appl. Publ., 8 pp. CODEN: USXXCO
- DT Patent
- LA English

FAN.CNT 1

	9-1						
	PATENT NO.	KIND	DATE	TE APPLICATION NO.			
ΡI	US 20050062350	A1	20050324	US 2003-645420			
					200308		
					21		

PRAI US 2003-645420 20030821

AB The ability of a lubricating grease to support an elec. voltage when functioning in an elec. motor is decreased by mixing elec. conducting particles with the grease to form a conductive grease. Suitable conducting particles consist of a combination of carbon (or carbon black) and a metal, in which the particles are coated with a conducting polymer. Suitable conducting polymers include polyacetylene, polyphenylene, polyphenylene, polyphenylene, polyphenylene, polyphene, polythiophene, poly(3-

alkylthiophenes), polyazulene, polyfuran, and polyaniline. The grease is suitable for use in motors that include a frame, a stator fixed relative to the frame, a bearing assembly fixed relative to the frame, and a rotor supported by the bearing assembly for rotation relative to the stator.

IT 91201-85-3, Polyisothianaphthene

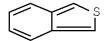
RL: TEM (Technical or engineered material use); USES (Uses) (coating, lubricating greases containing; elec. conducting lubricating greases containing conducting polymers, especially for elec. motors and bearing assemblies)

RN 91201-85-3 HCAPLUS

CN Benzo[c]thiophene, homopolymer (CA INDEX NAME)

CM 1

CRN 270-82-6 CMF C8 H6 S



IC ICM H02K005-16

ICS H02K011-00 INCL 310090000; 508410000; 310071000

CC 51-8 (Fossil Fuels, Derivatives, and Related Products)

11 110-02-1D, Thiophene, 3-alkyl derivs., polymers 9033-83-4, Poly(phenylene) 25067-54-3, Polyfuran 25067-58-7, Polyacetylene 25233-30-1, Polyaniline 25233-34-5, Polythiophene 30604-81-0, Polypyrrole 82451-56-7, Polyazulene 91201-85-3, Polyisothianaphthene 96638-49-2, Polyphenylenevinylene

RL: TEM (Technical or engineered material use); USES (Uses) (coating, lubricating greases containing; elec. conducting lubricating greases containing conducting polymers, especially for elec. motors and bearing assemblies)

L30 ANSWER 13 OF 33 HCAPLUS COPYRIGHT 2008 ACS on STN

AN 2004:651398 HCAPLUS Full-text

DN 141:182917

TI Ink containing electrically conductive polymer microcapsules and laminated sheet using the ink for formation of electric circuit

IN Umeda, Makoto

PA Toppan Forms Co., Ltd., Japan

SO Jpn. Kokai Tokkyo Koho, 9 pp.

CODEN: JKXXAF

DT Patent

LA Japanese

FAN.CNT 1

	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
ΡI	JP 2004224835	А	20040812	JP 2003-11419	200301

PRAI JP 2003-11419

20030120

AB The ink contains the microcapsules made of cores containing an elec. conductive conjugated polymer and an elec. insulating material as walls. The sheet is that obtained from the 1st substrate having an elec. circuit involving elec. insulating portions, which is formed by the ink, and the 2nd substrate laminated at least on the elec. insulator portion through a pressure-sensitive adhesive layer. The 2nd substrate is peeled off so that the microcapsules are broken and that elec. insulator portion is converted to an elec. circuit on the 1st substrate.

IT 91201-85-3, Polyisothianaphthene

RL: TEM (Technical or engineered material use); USES (Uses)

(ink containing elec. conductive polymer

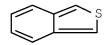
microcapsules for laminated sheet for formation of elec. circuit)

RN 91201-85-3 HCAPLUS

CN Benzo[c]thiophene, homopolymer (CA INDEX NAME)

CM 1

CRN 270-82-6 CMF C8 H6 S



IC ICM C09D011-02

ICS H01B001-20; H01B005-14; H05K003-12

CC 76-2 (Electric Phenomena)

Section cross-reference(s): 38, 42

IT 9033-83-4, Polyphenylene 25067-54-3, Polyfuran 25067-58-7, Polyacetylene 25135-16-4, Polynaphthalene 25212-74-2,

Poly(thio-1,4-phenylene) 25233-30-1, Polyaniline 25233-34-5, Polythiophene 30604-81-0, Polypyrrole 41496-25-7, Polypyrene 82451-56-7, Polyazulene 89231-09-4, Polyselenophene 91201-85-3, Polyisothianaphthene 96638-49-2, Poly(phenylene vinylene) 114239-80-4, Polyperinaphthalene 152633-31-3

RL: TEM (Technical or engineered material use); USES (Uses) (ink containing elec. conductive polymer microcapsules for laminated sheet for formation of elec. circuit)

L30 ANSWER 14 OF 33 HCAPLUS COPYRIGHT 2008 ACS on STN

AN 2004:271590 HCAPLUS Full-text

DN 140:311998

TI Antistatic agent for antistatic film covering chemically amplified resist film, pattern formation using the antistatic film, and its

IN Saita, Yoshihiro; Abe, Shinyoku

PA Showa Denko K. K., Japan

SO Jpn. Kokai Tokkyo Koho, 20 pp. CODEN: JKXXAF

DT Patent

LA Japanese

FAN.CNT 1

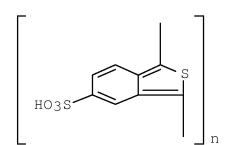
	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
PI	JP 2004099678	A	20040402	JP 2002-260957	200209 06
PRAI OS GI	JP 4040938 JP 2002-260957 MARPAT 140:311998	В2	20080130 20020906		

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The antistatic agent with good pH stability contains water-soluble elec. conductive polymers, fluorinated aliphatic amines, and water. Preferably, the amines comprise ≥1 represented by the general formula X(CF2)mCY2NH2 (X = F, OH; Y = H, F; m = 1-10 integer), more preferably, trifluoroethylamine. Preferably, the water-soluble elec. conductive polymers comprise π -conjugated ones bearing Broensted acid groups, more preferably, sulfonic acid groups. More preferably, the water-soluble elec. conductive polymers are represented by general formulas I [m, n = 0, 1; A = C1-4 alkylene, C1-4 alkenylene which]have ≥1 BSO3-M, may be substituted with halo, OH, NO2, etc., and may contain ≥ 2 C:C; B = (CH2)p[O(CH2)q]r; p = 0-5 integer, q = 1-3 integer, r = 0-3 integer; M = H+, alkali metal ion, quaternary ammonium ion], II or III [R1-R5 = H, C1-20 hydrocarbyl, alkoxy, alkylester, OH, halo, NO2, BSO3M, etc.; alkyl, alkoxy, or alkylester groups of R1-R5 may contain CO, ether, CO2, SO3, amido, sulfoneamido, sulfide, S(0), SO2, :NH, thioether in the chain; R6 = H, C1-20hydrocarbyl or Ph which may be substituted; B, p, q, r, M = same as I]. The water-soluble elec. conductive polymers may contain 5sulfoisothianaphthene-1,3-diyl as the chemical structure. antistatic treatment agent amy contain surfactants. Chemicalamplified resist films are covered with films of the antistatic treatment agent. Semiconductor elements, photomasks, reticles, glass substrates, quartz substrates, GMR heads, or magnetic substrates are fabricated by using the antistatic treatment agent.

ΙΙ



IC ICM C09K003-16 ICS C08G061-12; C08L079-00; G03F007-11; H01L021-027

CC 74-5 (Radiation Chemistry, Photochemistry, and Photographic and Other Reprographic Processes)

Section cross-reference(s): 38, 76, 77

IT 188754-53-2, Poly(5-sulfoisothianaphthene-1,3-diyl)

RL: TEM (Technical or engineered material use); USES (Uses) (buffered water-soluble elec. conductive polymer-based antistatic agent for antistatic coating on chemical amplified resist film, its patterning, and its use)

L30 ANSWER 15 OF 33 HCAPLUS COPYRIGHT 2008 ACS on STN

AN 2002:693651 HCAPLUS Full-text

DN 137:234047

TI Actuators and their manufacture

IN Kito, Yasuhiko

PA Japan

SO Jpn. Kokai Tokkyo Koho, 8 pp.

CODEN: JKXXAF

DT Patent

LA Japanese

FAN.CNT 1

	PATENT NO.	KIND	ND DATE APPLICATION NO.			
ΡI	JP 2002262542	А	20020913	JP 2001-57052		

200103

PRAI JP 2001-57052

20010301

Title actuators, having good softness, response, and controllability, consist of (A) elec. insulating polymeric films and (B) elec. conductive polymeric films which are located on top of the A films and have main chain direction parallel to and almost the same direction as the A films; the B films could further form into tubular or folded shape along the main chain direction. The actuators are prepared by ionizing the elec. conductive polymer vapors or sprayionizing solns. containing the elec. conductive polymer precursors (e.g., monomers or oligomers), followed by elec. adsorbing onto the A films in presence of magnetic field. Detailed illustrations are presented and elec. conductive polymers are preferably polymers containing Bronsted acid groups with dopant ability e.g., isothianaphthene-isothianaphthene-5-sulfonic acid copolymer, etc.

IT 181815-09-8

RL: PEP (Physical, engineering or chemical process); PYP (Physical process); TEM (Technical or engineered material use); PROC (Process); USES (Uses)

(manufacture of elec. conductive polymer

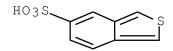
-laminated insulating polymer film actuators by ion-vapor deposition)

RN 181815-09-8 HCAPLUS

CN Benzo[c]thiophene-5-sulfonic acid, polymer with benzo[c]thiophene (9CI) (CA INDEX NAME)

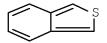
CM 1

CRN 181815-07-6 CMF C8 H6 O3 S2



CM 2

CRN 270-82-6 CMF C8 H6 S



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IC ICM H02K033-00
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ICS C08J007-04; C08L101-00

CC 42-2 (Coatings, Inks, and Related Products) Section cross-reference(s): 76

IT 152950-70-4 181815-09-8

RL: PEP (Physical, engineering or chemical process); PYP (Physical process); TEM (Technical or engineered material use); PROC (Process); USES (Uses)

(manufacture of elec. conductive polymer

-laminated insulating polymer film actuators by ion-vapor deposition)

- L30 ANSWER 16 OF 33 HCAPLUS COPYRIGHT 2008 ACS on STN
- AN 2001:910860 HCAPLUS Full-text
- DN 136:297278
- TI Hybrid solar cells based on dye-sensitized nanoporous TiO2 electrodes and conjugated polymers as hole transport materials
- AU Gebeyehu, D.; Brabec, C. J.; Sariciftci, N. S.; Vangeneugden, D.; Kiebooms, R.; Vanderzande, D.; Kienberger, F.; Schindler, H.
- CS Linz Institute for Organic Solar Cells (LIOS), Physical Chemistry, Johannes Kepler University of Linz, Linz, A-4040, Austria
- SO Synthetic Metals (2001), Volume Date 2002, 125(3), 279-287 CODEN: SYMEDZ; ISSN: 0379-6779
- PB Elsevier Science S.A.
- DT Journal
- LA English
- AB Solid state dye-sensitized photovoltaic solar cells were fabricated using a three-layer concept. The hybrid devices consist of a transparent inorg. nanocryst. titanium dioxide (nc-TiO2) layer with a thickness of 2 μm as electron acceptor and for electron transport. A surface-adsorbed RuL2(NCS)2:2 TBA dye complex (where L is 2,2'-bipyridyl-4,4'-dicarboxylic acid; TBA is tetrabutylammonium) is used for light absorption and electron injection to the conduction band of TiO2. For the transport of holes to the back-contact electrode, conjugated polymers were used, either a poly(3-octylthiophene) or a low-band-gap thiophene-isothianaphthene-based copolymer. These devices exhibited an overall energy conversion efficiency of .apprx.0.16% under simulated solar irradiation (80 mW/cm2). Furthermore, the surface network morphol. of these film layers were

Referenced

(RAU)

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strategies to improve conversion efficiency.
ΙT
     355142-55-1, Benzo[c]thiophene, polymer with thiophene
     RL: DEV (Device component use); USES (Uses)
        (low-band-gap; hybrid solar cell with dye-sensitized titania
        electrode and conjugated conducting
        polymers)
     355142-55-1 HCAPLUS
RN
     Benzo[c]thiophene, polymer with thiophene (9CI) (CA INDEX NAME)
CN
     СМ
          1
     CRN 270-82-6
     CMF C8 H6 S
     CM
          2
         110-02-1
     CRN
     CMF C4 H4 S
     52-2 (Electrochemical, Radiational, and Thermal Energy Technology)
CC
     Section cross-reference(s): 41
    355142-55-1, Benzo[c]thiophene, polymer with thiophene
ΙT
     RL: DEV (Device component use); USES (Uses)
        (low-band-gap; hybrid solar cell with dye-sensitized titania
        electrode and conjugated conducting
        polymers)
RETABLE
   Referenced Author | Year | VOL | PG | Referenced Work
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|(RPY)|(RVL)|(RPG)| (RWK)

| File

investigated by atomic microscope (AFM) in order to explore

=======================================	+=====	+=====	+=====	+======================================	+=======
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Arango, A	1999	74	1698	Appl Phys Lett	HCAPLUS
Argazzi, R	11994	133	5741	Inorg Chem	HCAPLUS
Bach, U	1998	395	583		HCAPLUS
Balzani, V	11998	31	126	·	HCAPLUS
Barbe, C	11997	80	3157	·	HCAPLUS
Bignozzi, C	1994	32	229	Sol Energy Mater Sol	
Campbell, I	1999	74	561		HCAPLUS
Cao, F	11995	99	117071		HCAPLUS
Ferber, J	11998	54	265	Sol Energy Mater Sol	•
Ferrere, S	1998	120	843		HCAPLUS
Ferrere, S	1997	101	4490	·	HCAPLUS
Gebeyehu, D	11999	1	89	Int J Photoenergy	Ì
Gebeyehu, D	1999	1	195	Intern J Photoenergy	HCAPLUS
Gratzel, M	1995	İ			HCAPLUS
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Green, M	1998	16	35	Prog Photovolt Res A	HCAPLUS
Greenham, N	1997	54	17628	Phys Rev B	İ
Hagen, J	1997	89	215	Synth Met	HCAPLUS
Halls, J	1996	68	3120	Appl Phys Lett	HCAPLUS
He, J	1997	101	9027	J Phys Chem B	HCAPLUS
Heimer, T	1996	35	5319	Inorg Chem	HCAPLUS
Huang, S	1997	101	2576	J Phys Chem B	HCAPLUS
Kajihara, K	1997	36	5537	Jpn Appl Phys	HCAPLUS
Kavan, L	1996	143	394	J Electrochem Soc	HCAPLUS
Kay, A	1993	97	6272	J Phys Chem	HCAPLUS
Kiebooms, R	1997	62	1473	J Org Chem	HCAPLUS
Meyer, G	1997	74	652	J Chem Educ	HCAPLUS
Murakoshi, K	1997			Chem Lett	[
Nazeeruddin, M	1997	1705		Chem Commun	1
Nazeeruddin, M	1993	115	6382	J Am Chem Soc	HCAPLUS
Nazeeruddin, M	1997	5471		J Chem Soc, Dalton T	1
O'Regan, B	1995	7	1349	Chem Mater	HCAPLUS
O'Regan, B	1991	353	737	Nature	HCAPLUS
Papageorgiou, N	1998	102	4156	J Phys Chem B	HCAPLUS
Park, Y	1996	68	2699	Appl Phys Lett	HCAPLUS
Parker, I	1994	75	1656	J Appl Phys	HCAPLUS
Ruile, S	1997	261	129	Inorg Chim Acta	HCAPLUS
Sariciftci, N	1998			Primary Photoexcitat	1
Savenije, T	1998	287	148	Chem Phys Lett	HCAPLUS
Savenije, T		61	9	Sol Energy Mater Sol	HCAPLUS
Schlichthorl, G	1997		8141	J Phys Chem B	1
Shaheen, S	2001	78	841		HCAPLUS
Tennakone, K	1998		1492	J Phys D: Appl Phys	HCAPLUS
·		•	1689	Sci Technol	1
Usami, A	1997	277	105	Chem Phys Lett	HCAPLUS

	gi,	Н				1996	1()3 43)0 54 5 59	447	١J	Ph	ys Ch	em		I	HCAF	LUS
TI IN PA SO	N 2000:686383 HCAPLUS <u>Full-text</u> N 133:274316 I Scratch resistant antistatic layer for imaging elements N Majumdar, Debasis; Anderson, Charles Chester Eastman Kodak Company, USA O Eur. Pat. Appl., 15 pp. CODEN: EPXXDW																
DT LA																	
FAN.	CNT	2															
	PAT	CENT	NO.			KINI	O	DATE			APP	LICAT	ION I	NO.		Γ	ATE
DT						·	_	20000	007								
ЬI	ĽР	1039	342			Al		200009	<i>9∠1</i>		EР	2000-	2008	94			200003
	EP	1039	342			В1		200505	504								
		R:						ES, E		GB,	GR	, IT,	LI,	LU,	NL,	SE,	MC,
	US	6187	522			B1		200102	213		US	1999-	2765.	30			.99903
	JP 2000298329			7\ 20		200010	n24		JP 2000-88543			25					
	01	2000	2,000			7.7		20001	<i>,</i>		01	2000	0004			2	200003

PRAI US 1999-276530 A 19990325

AB An imaging element comprises a support, an image-forming layer superposed on the support and an outermost scratch resistant antistatic layer with thickness $0.6-10~\mu$ superposed on the support. The scratch resistant layer is composed of a ductile polymer having a modulus >100 MPa measured at 20 °C and a tensile elongation to break >50%, a filler particle having a modulus >10 GPa, and an elec. conducting polymer. The volume ratio of the polymer to the filler particle is between 70:30 and 40:60 and the elec.-conducting polymer is present at a weight concentration based on a total dried weight of the scratch resistant layer of 1-10 weight%. The ductile polymer may be a polycarbonate, polyurethane, or polyolefin. The elec.conducting polymer may be a substituted or unsubstituted pyrrolecontaining polymer, a substituted or unsubstituted thiophenecontaining polymer, a substituted or unsubstituted aniline-containing polymer, or polyisothianaphthene, especially polypyrrole styrene sulfonate or 3,4-dialkoxy substituted polypyrrole styrene sulfonate.

24

The hard filler may be colloidal SiO2, colloidal tin oxide, colloidal TiO2, mica, clays, doped metal oxides, metal oxides with oxygen deficiencies, metal antimonates, conductive nitrides, carbides or borides.

IT 91201-85-3, Polyisothianaphthene

RL: TEM (Technical or engineered material use); USES (Uses) (elec. conducting polymer; scratch

resistant antistatic layer containing ductile polymer and hard filler

and elec. conducting polymer for

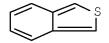
imaging elements)

RN 91201-85-3 HCAPLUS

CN Benzo[c]thiophene, homopolymer (CA INDEX NAME)

CM 1

CRN 270-82-6 CMF C8 H6 S



IC ICM G03C001-76

ICS G03G005-147; B41M005-40

CC 74-9 (Radiation Chemistry, Photochemistry, and Photographic and Other Reprographic Processes)

IT 91201-85-3, Polyisothianaphthene

RL: TEM (Technical or engineered material use); USES (Uses) (elec. conducting polymer; scratch

resistant antistatic layer containing ductile polymer and hard filler

and elec. conducting polymer for

imaging elements)

RETABLE

Referenced Author | Year | VOL | PG | Referenced Work | Referenced |(RPY)|(RVL)|(RPG)| (RWK) _____+ 3M |1997 | |WO 9738358 A | HCAPLUS Aqfa-Gevaert |1994 | |EP 0602713 A | HCAPLUS |1997 | Zumbulyadis |US 5674654 A | HCAPLUS

L30 ANSWER 18 OF 33 HCAPLUS COPYRIGHT 2008 ACS on STN

AN 1997:289842 HCAPLUS Full-text

DN 126:264787

OREF 126:51279a,51282a

TI Antistatic film-containing compositions, films therefrom, antistatic film-containing supports used in image-forming devices, fixation rollers, and manufacture thereof

IN Kato, Junya; Ohira, Manabu

PA Showa Denko K. K., Japan

SO Jpn. Kokai Tokkyo Koho, 11 pp.

CODEN: JKXXAF

DT Patent

LA Japanese

FAN.CNT 1

r AN•	PATENT NO.	KIND	ND DATE APPLICATION NO.		DATE -
PI	 JP 09048921	A	19970218	JP 1995-199966	199508
	JP 3629762 JP 2004300443	B2 A	20050316 20041028	JP 2004-130017	04
	JP 3902194	В2	20070404		200404 26
	JP 2005025209	A	20050127	JP 2004-217788	200407 26
	JP 4160025	В2	20081001		
	JP 2007119784	А	20070517	JP 2006-294952	200610 30
	JP 4131335	В2	20080813		
	JP 2008150616	A	20080703	JP 2008-10966	200801 21
PRAI	JP 1995-199966	A3	19950804		
	JP 2004-130017	A3	20040426		
7. TO	JP 2006-294952	A3	20061030		

AB The title compns. controlling the title support surface resistance to certain ranges of semiconductor region comprise elec. conductive π -conjugated polymers, resin, and solvent. Thus, a ball-milled composition from Nippolan 5137 (polyurethane) 100 dissolved in water 12, and poly(1,3-isothianaphthenylene-5-sulfonate) 3 g was coated on a dielec. Bu rubber plate to obtain a coating film showing surface

resistant 1 x 1011 Ω /.box. (85% humidity) and 6 x 1011 Ω /.box. (10% humidity).

IT 188754-53-2, Poly(5-sulfobenzo[c]thiophene-1,3-diyl)

RL: MOA (Modifier or additive use); TEM (Technical or engineered material use); USES (Uses)

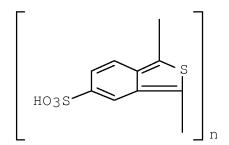
(antistatic film-forming compns. containing elec.

conductive π -conjugated polymers for elec.

resistance control of imaging device supports)

RN 188754-53-2 HCAPLUS

CN Poly(5-sulfobenzo[c]thiophene-1,3-diyl) (CA INDEX NAME)



IC ICM C08L101-12

ICS C08G061-12; C08L065-00; C09D201-00; G03G015-20

CC 37-3 (Plastics Manufacture and Processing)

Section cross-reference(s): 42, 74

IT 32036-19-4, Poly(1,4-iminophenylene) 139439-92-2,

Poly[3-(3-sulfopropyl)-2,5-thiophenediyl] 188754-53-2,

Poly(5-sulfobenzo[c]thiophene-1,3-diyl) 188754-54-3,

Poly(1-octyl-1H-pyrrole-2,5-diyl)

RL: MOA (Modifier or additive use); TEM (Technical or engineered material use); USES (Uses)

(antistatic film-forming compns. containing elec.

conductive π -conjugated polymers for elec.

resistance control of imaging device supports)

L30 ANSWER 19 OF 33 HCAPLUS COPYRIGHT 2008 ACS on STN

AN 1997:215994 HCAPLUS Full-text

DN 126:293790

OREF 126:56899a,56902a

TI Evidence of quinonoid structures in the vibrational spectra of thiophene based conducting polymers: poly(thiophene), poly(thieno[3,4-b]benzene), and poly(thieno[3,4-b]pyrazine)

AU Cuff, Lilee; Kertesz, Miklos

CS Dep. Chem., Georgetown Univ., Washington, DC, 20057-1227, USA

SO Journal of Chemical Physics (1997), 106(13), 5541-5553 CODEN: JCPSA6; ISSN: 0021-9606

PB American Institute of Physics

DT Journal

LA English

By combining vibrational spectra and ab initio calcns., a consistent AB description was obtained, of the IR and nonresonant Raman spectra, including intensities, of four thiophene based polymers-undoped and heavily doped poly(thiophene) (PTh), undoped poly(thieno[3,4b]benzene) (PITN), nd poly(thieno[3,4-b]pyrazine) (PThP). Predicted spectra for poly(thiophene) agree with experiment well. Based on the calculated force consts. and Badger's rule, the average inter-ring bond length of undoped and doped PTh were estimated to be 1.47 and 1.42 Å, resp. The latter leads to an estimated 33% quinonoid character on average for heavily doped PTh. The average inter-ring bond length of undoped PITN and PThP, are consistent with their vibrational spectra and are estimated to be 1.41, and 1.42 Å, resp. These values showed that undoped PITN and PThP have quinonoid character close to that of heavily doped PTh. Upon doping, the average bond lengths of PTh changed by -0.01, 0.11, and -0.05 Å for intra-ring $C\beta$ - $C\beta$, $C\alpha$ - $C\beta$, and inter-ring bonds, resp. These bond length changes are significantly different from those of Hartree-Fock-type calcns., reflecting significant correlation contributions and are also in conflict with earlier empirical fits of the vibrational spectrum of the highly doped phase of PTh. these results are more in line with the generally accepted picture of an aromatic to quinonoid transition of the doping process. Furthermore, the counterintuitive downward frequency shifts in the vibrational spectra of PTh upon doping can be explained by the structural change from an essentially aromatic to a partially quinonoid form.

IT 91201-85-3

RL: PRP (Properties)

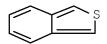
(evidence of quinonoid structures in vibrational spectra of polythiophene, poly(thienobenzene), and poly(thienopyrazine) conducting polymers)

RN 91201-85-3 HCAPLUS

CN Benzo[c]thiophene, homopolymer (CA INDEX NAME)

CM 1

CRN 270-82-6 CMF C8 H6 S



CC 36-2 (Physical Properties of Synthetic High Polymers)

Section cross-reference(s): 76

IT 25233-34-5, Poly(thiophene) 91201-85-3 125541-34-6,

Poly(thieno[3,4-b]pyrazine)

RL: PRP (Properties)

(evidence of quinonoid structures in vibrational spectra of polythiophene, poly(thienobenzene), and poly(thienopyrazine)

Referenced Author | Year | VOL | PG | Referenced Work |

conducting polymers)

RE	Τ	Α	В	L	Ε
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Referenced					
(RAU)	(RPY)	(RVL)	(RPG)	(RWK)	File
	+=====	+====	+=====	+=========	+======
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Akimoto, M		•	353	. 4	HCAPLUS
Allen, W		•	6834	J Am Chem Soc	HCAPLUS
Badger, R	1934	2	128	J Chem Phys	HCAPLUS
Badger, R	1935	3	193	J Chem Phys	
Bak, B	1961	7	58	J Mol Spectrosc	HCAPLUS
Baker, G	1988		271	Electronic and Photo	HCAPLUS
Belsky, V	1984	40	1210	Acta Crystallogr C	
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Cuff, L	1993	55	564	Synth Met	HCAPLUS
Cui, C	1990	93	5257	J Chem Phys	HCAPLUS
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Furukawa, Y	1987	18	151	Synth Met	HCAPLUS
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Hoogmartens, I	1991	14/1-		Synth Met	
Ikenoue, Y	1991	40	1	Synth Met	HCAPLUS
Karpfen, A	1991	195	7680	J Phys Chem	HCAPLUS
Kastner, J	1995	128	2922	Macromolecules	HCAPLUS
Kertesz, M	1995	69	641	Synth Met	HCAPLUS
Kobayashi, M	1985	182	5717	J Chem Phys	HCAPLUS
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Kurti, J	1990	192	3247	J Chem Phys	HCAPLUS
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Vardeny, Z	1987	18	183	Synth Met	HCAPLUS
Wilson, E	1995			Molecular Vibrations	
Wudl, F	1984	136	3382	J Org Chem	
Yong, C	1985	54	211	Solid State Commun	
Zerbi, G	1991		435	Conjugated Polymers	HCAPLUS
Zerbi, G	1991	94	4637	J Chem Phys	HCAPLUS

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L30 ANSWER 20 OF 33 HCAPLUS COPYRIGHT 2008 ACS on STN
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AN 1996:687011 HCAPLUS <u>Full-text</u>

DN 125:312552

OREF 125:58239a,58242a

TI Rubbing process for aligning LCD orientation film

IN Oohira, Manabu; Motohashi, Naoko; Ikenoe, Yoshiaki

PA Showa Denko Kk, Japan

SO Jpn. Kokai Tokkyo Koho, 11 pp.

CODEN: JKXXAF

DT Patent LA Japanese

FAN.CNT 1

	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
PI	 JP 08211391	А	19960820	JP 1995-19467	199502 07
PRAI GI	JP 1995-19467		19950207		

I

AB The rubbing process is carried out after applying an antistatic agent containing a conjugated elec. conductive polymer on the orientation film. The conjugated elec. conductive polymer may be represented by I (R1-5 = H, C1-10 alkyl, C1-10 alkoxy, halo, S03M-; M = H+, alkali metal ion, quaternary ammonium ion; k = 0-3). Preferably, the conjugated elec. conductive polymer may be poly(2-sulfoaniline-co-aniline) or poly(5-isothianaphthenesulfonic acid-co-isothianaphthene). The conjugated elec. conductive polymer film is removed after the rubbing process.

IT 181815-08-7 181815-09-8 181815-12-3

RL: MOA (Modifier or additive use); USES (Uses) (conjugated elec. conductive polymer in LCD orientation film)

RN 181815-08-7 HCAPLUS

CN Benzo[c]thiophene-5-sulfonic acid, homopolymer (9CI) (CA INDEX NAME)

CM 1

CRN 181815-07-6

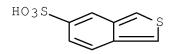
CMF C8 H6 O3 S2

RN 181815-09-8 HCAPLUS

CN Benzo[c]thiophene-5-sulfonic acid, polymer with benzo[c]thiophene (9CI) (CA INDEX NAME)

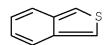
CM 1

CRN 181815-07-6 CMF C8 H6 O3 S2



CM 2

CRN 270-82-6 CMF C8 H6 S

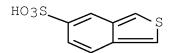


RN 181815-12-3 HCAPLUS

CN Benzo[c]thiophene-5-sulfonic acid, ammonium salt, homopolymer (9CI) (CA INDEX NAME)

CM 1

CRN 181815-11-2 CMF C8 H6 O3 S2 . H3 N



NH3

IT 183210-05-1

RL: MOA (Modifier or additive use); PEP (Physical, engineering or chemical process); PROC (Process); USES (Uses)

(conjugated elec. conductive polymer

in LCD orientation film)

RN 183210-05-1 HCAPLUS

CN Naphtho[2,3-c]thiophene-6-sulfonic acid, homopolymer (9CI) (CA INDEX NAME)

CM 1

CRN 183210-04-0 CMF C12 H8 O3 S2

IC ICM G02F001-1337

ICS C08G061-12

CC 74-13 (Radiation Chemistry, Photochemistry, and Photographic and Other Reprographic Processes)

Section cross-reference(s): 38, 76

IT 135899-67-1, Poly(3-(3'-thienyl)propanesulfonic acid) 146526-57-0 181815-08-7 181815-09-8 181815-12-3

RL: MOA (Modifier or additive use); USES (Uses)

(conjugated elec. conductive polymer

in LCD orientation film)

ΙT 183210-05-1

> RL: MOA (Modifier or additive use); PEP (Physical, engineering or chemical process); PROC (Process); USES (Uses)

(conjugated elec. conductive polymer

in LCD orientation film)

ANSWER 21 OF 33 HCAPLUS COPYRIGHT 2008 ACS on STN L30

ΑN 1996:571835 HCAPLUS Full-text

DN 125:208292

OREF 125:38725a,38728a

Antistatic coating composition and plastic film bearing antistatic ΤI layer for silver halide photographic material

Tachibana, Noriki; Okamura, Shinichi; Morita, Seiwa; Kotani, Chiaki IN

Konishiroku Photo Ind, Japan PA

Jpn. Kokai Tokkyo Koho, 64 pp. SO

CODEN: JKXXAF

DT Patent

LA Japanese

FAN.CNT 1

	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
ΡI	JP 08160568	А	19960621	JP 1994-302273	
					199412

2 06

PRAI JP 1994-302273

19941206

The title coating process composition is an aqueous dispersion or AB solution containing a π -electron conductive polymer and an acceptor dopant, which contains Ca ion concentration ≤ 500 ppm. The π -electron conductive polymer, and the plastic film bearing the antistatic layer as support for Aq halide photoq. material are also claimed.

91201-85-3 133184-17-5 162370-00-5 ΙT 181226-88-0

> RL: DEV (Device component use); TEM (Technical or engineered material use); USES (Uses)

(electron conductive polymer for

antistatic coating and photog. film)

91201-85-3 HCAPLUS RN

Benzo[c]thiophene, homopolymer (CA INDEX NAME) CN

CM 1

CRN 270-82-6 CMF C8 H6 S

10593498

RN 133184-17-5 HCAPLUS

CN Benzo[c]thiophene, 5-ethyl-, homopolymer (9CI) (CA INDEX NAME)

CM 1

CRN 133184-16-4 CMF C10 H10 S

RN 162370-00-5 HCAPLUS

CN Benzo[c]thiophene, 5-[(octyloxy)methyl]-, homopolymer (9CI) (CA INDEX NAME)

CM 1

CRN 162369-99-5 CMF C17 H24 O S

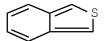
RN 181226-88-0 HCAPLUS

CN 2-Propenoic acid, butyl ester, polymer with benzo[c]thiophene, graft (9CI) (CA INDEX NAME)

CM 1

CRN 270-82-6

CMF C8 H6 S



CM 2

CRN 141-32-2 CMF C7 H12 O2

ICM G03C001-85

TC

```
ICS G03C001-89
CC
    74-2 (Radiation Chemistry, Photochemistry, and Photographic and
    Other Reprographic Processes)
                25233-34-5
                            25988-40-3 27082-18-4 30604-81-0
    25067-54-3
ΙT
    30639-56-6
                33411-63-1 89761-73-9 91201-85-3
    104934-53-4 105935-08-8 110847-38-6 122721-92-0
    133184-17-5 137539-66-3 162370-00-5
    181226-79-9 181226-81-3 181226-82-4 181226-84-6
                                                         181226-85-7
    181226-86-8 181226-87-9 181226-88-0
    RL: DEV (Device component use); TEM (Technical or engineered
```

material use); USES (Uses)

(electron conductive polymer for

(electron conductive polymer for antistatic coating and photog. film)

L30 ANSWER 22 OF 33 HCAPLUS COPYRIGHT 2008 ACS on STN

AN 1996:229032 HCAPLUS Full-text

DN 124:304251

OREF 124:56111a,56114a

TI Electrically conductive polymeric compositions

IN Hedges, Winston L.

PA Hexcel Corp., USA

SO U.S., 12 pp., Cont.-in-part of U.S. Ser. No. 930,738.

CODEN: USXXAM

DT Patent LA English FAN.CNT 3

ran.	PATENT NO.	KIND 	DATE	APPLICATION NO.	DATE
ΡI	us 5498372	А	19960312	US 1994-195399	199402
	US 6132645	А	20001017	US 1992-930738	14 199208
PRAI	: US 1992-930738	A2	19920814		14

19921106

OS MARPAT 124:304251

US 1992-972574

AB Elec. conductive polymeric compns. suitable for fabricating devices for safely transporting volatile chems. and fuels are disclosed. The elec. conductive polymeric compns. include ≥1 nonconductive matrix polymer and an elec. conductive filler material incorporated in the matrix polymer in an amount sufficient to provide the conductive polymeric composition with an elec. conductivity of ≥10-10 S/cm. The elec. conductive filler material is intrinsically conductive polymer-coated C black particles. The coating of intrinsically elec. conductive polymer provides a protective shield against loss of particle conductivity, contributes to the overall conductivity of the filler material, and enhances the mech. properties of the filled matrix polymer.

IT 91201-85-3, Polyisothianaphthene

RL: TEM (Technical or engineered material use); USES (Uses) (elec. conductive polymeric compns.

containing carbon black particles coated with)

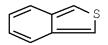
RN 91201-85-3 HCAPLUS

CN Benzo[c]thiophene, homopolymer (CA INDEX NAME)

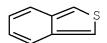
Α2

CM 1

CRN 270-82-6 CMF C8 H6 S



```
IC
     ICM H01B001-12
     ICS H01B001-24
INCL 252511000
     76-2 (Electric Phenomena)
CC
     Section cross-reference(s): 38
ΙT
     9033-83-4, Polyphenylene 25067-54-3, Polyfuran 25067-58-7,
                     25233-30-1, Polyaniline
     Polvacetylene
                                              25233-34-5, Polythiophene
     30604-81-0, Polypyrrole 82451-56-7, Polyazulene 91201-85-3
     , Polyisothianaphthene 96638-49-2, Polyphenylenevinylene
     RL: TEM (Technical or engineered material use); USES (Uses)
        (elec. conductive polymeric compns.
        containing carbon black particles coated with)
L30
     ANSWER 23 OF 33 HCAPLUS COPYRIGHT 2008 ACS on STN
AN
     1996:16256 HCAPLUS Full-text
DN
     124:57318
OREF 124:10845a,10848a
ΤI
     Quantum mechanical study of the vibrational spectrum-structure
     relationship of conjugated conducting polymers
     Cuff, Lilee
ΑU
CS
     Georgetown Univ., Washington, DC, USA
SO
     (1995) 192 pp. Avail.: Univ. Microfilms Int., Order No. DA9534195
     From: Diss. Abstr. Int., B 1995, 56(6), 3214
DT
    Dissertation
LA
    English
     Unavailable
AB
     91201-85-3, Poly(benzo[c]thiophene)
ΙΤ
     RL: PRP (Properties)
        (quantum mech. study of vibrational spectrum-structure
        relationship of conjugated conducting polymers
        )
RN
     91201-85-3 HCAPLUS
     Benzo[c]thiophene, homopolymer (CA INDEX NAME)
CN
     CM
          1
     CRN 270-82-6
     CMF C8 H6 S
```

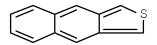


CM

1

```
CC
     36-5 (Physical Properties of Synthetic High Polymers)
     Section cross-reference(s): 76
ΙΤ
     25190-62-9, Poly(p-phenylene)
                                     25233-34-5, Polythiophene
     91201-85-3, Poly(benzo[c]thiophene) 125541-34-6
     RL: PRP (Properties)
        (quantum mech. study of vibrational spectrum-structure
        relationship of conjugated conducting polymers
        )
     ANSWER 24 OF 33 HCAPLUS COPYRIGHT 2008 ACS on STN
L30
     1996:15033 HCAPLUS
AN
                          Full-text
     124:57339
DN
OREF 124:10849a,10852a
ΤI
     Theoretical tailoring of electrically conducting polymers: some new
     results
ΑU
     Bakhshi, A. K.
     Dep. Chem., Panjab University, Chandigarh, 160 014, India
CS
SO
     Materials Science & Engineering, C: Biomimetic Materials, Sensors
     and Systems (1995), C3(3-4), 249-55
     CODEN: MSCEEE; ISSN: 0928-4931
PΒ
     Elsevier
DT
     Journal
     English
LA
AB
     Methods for design of conducting polymers, including substitution,
     ladder structure formation, topol. methods and polymeric superlattice
     formation are outlined. Using these routes, the electronic structure
     and conduction of polythiazoles and the nitrogen- and oxygen-
     containing analogs of poly(isonaphthothiophene) (PINTP) were
     determined, on the basis of ab initio Hartree-Fock crystal orbital
     calcns. Calculated data show that the simultaneous presence of
     nitrogen and sulfur within a single ring in polythiazoles makes the
     latter less conducting than polythiophene. In the case of nitrogen-
     and oxygen-containing analogs of PINTP, results predict the nitrogen
     analog poly(isonaphthopyrrole) (PINPY) to be less conducting, and the
     oxygen-containing analog poly(isonaphthofuran) (PINFU) to be more
     conducting than PINTP in the intrinsic state.
     107949-39-3, Poly(isonaphthothiophene)
ΙT
     RL: PRP (Properties)
        (Hartree-Fock orbital calcn. of electronic structure and
        conduction of isonaphthothiophene analog conducting
        polymers)
     107949-39-3 HCAPLUS
RN
CN
     Naphtho[2,3-c]thiophene, homopolymer (9CI) (CA INDEX NAME)
```

CRN 268-55-3 CMF C12 H8 S



CC 36-5 (Physical Properties of Synthetic High Polymers) Section cross-reference(s): 76

IT 51325-08-7, Poly(2,5-thiazolediyl) 107949-39-3, Poly(isonaphthothiophene) 121718-43-2, Poly(isonaphthopyrrole) 172518-51-3, Poly(isonaphthofuran)

RL: PRP (Properties)

(Hartree-Fock orbital calcn. of electronic structure and conduction of isonaphthothiophene analog conducting polymers)

L30 ANSWER 25 OF 33 HCAPLUS COPYRIGHT 2008 ACS on STN

AN 1995:849559 HCAPLUS Full-text

DN 123:342807

OREF 123:61507a,61510a

TI Electrically conducting polymer molding compositions or film-forming compositions

IN Shimizu, Takeo; Kitano, Masakazu

PA Unitika Ltd, Japan

SO Jpn. Kokai Tokkyo Koho, 7 pp.

CODEN: JKXXAF

DT Patent

LA Japanese

FAN.CNT 1

	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
ΡI	JP 07188399	А	19950725	JP 1993-331438	
					199312
					27
					<u> </u>

PRAI JP 1993-331438 19931227

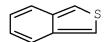
AB The title compns. contain moldable or film-formable polymers, and 1-50% monomers capable of forming elec. conducting polymers. Thus, poly(Me methacrylate) was mixed with 10% benzo[c]thiophene, spin-coated on glass, covered with a photo mask, and irradiated by UV to give a patterned product with conductivity 2 + 10-4 S/cm.

IT 91201-85-3, Benzo[c]thiophene homopolymer

```
107949-39-3, Naphtho[2,3-c]thiophene homopolymer
121311-73-7 129701-96-8, Naphtho[1,2-c]thiophene
homopolymer 171248-55-8 171248-56-9
RL: TEM (Technical or engineered material use); USES (Uses)
        (elec. conducting polymer molding
        compns. and films)
RN 91201-85-3 HCAPLUS
CN Benzo[c]thiophene, homopolymer (CA INDEX NAME)

CM 1

CRN 270-82-6
CMF C8 H6 S
```

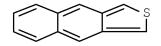


RN 107949-39-3 HCAPLUS
CN Naphtho[2,3-c]thiophene, homopolymer (9CI) (CA INDEX NAME)

CM 1

CRN 268-55-3

CMF C12 H8 S



```
RN 121311-73-7 HCAPLUS
CN Benzo[1,2-c:3,4-c']dithiophene, homopolymer (9CI) (CA INDEX NAME)

CM 1

CRN 23062-31-9

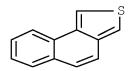
CMF C10 H6 S2
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RN 129701-96-8 HCAPLUS

CN Naphtho[1,2-c]thiophene, homopolymer (9CI) (CA INDEX NAME)

CM 1

CRN 232-81-5 CMF C12 H8 S



RN 171248-55-8 HCAPLUS

CN Benzo[1,2-b:3,4-c']dithiophene, homopolymer (9CI) (CA INDEX NAME)

CM 1

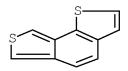
CRN 70259-52-8 CMF C10 H6 S2

RN 171248-56-9 HCAPLUS

CN Benzo[2,1-b:3,4-c']dithiophene, homopolymer (9CI) (CA INDEX NAME)

CM 1

CRN 27618-78-6 CMF C10 H6 S2



IC ICM C08G061-12

ICS H01B001-12

CC 38-3 (Plastics Fabrication and Uses) Section cross-reference(s): 37, 76

IT 9011-14-7, Poly(methyl methacrylate) 91201-85-3,

Benzo[c]thiophene homopolymer 94479-77-3 98507-51-8

106070-61-5 107949-39-3, Naphtho[2,3-c]thiophene

homopolymer 117533-13-8 120496-10-8 121311-72-6

121311-73-7 129701-96-8, Naphtho[1,2-c]thiophene

homopolymer 135798-61-7 171248-54-7 171248-55-8

171248-56-9

RL: TEM (Technical or engineered material use); USES (Uses)

(elec. conducting polymer molding

compns. and films)

L30 ANSWER 26 OF 33 HCAPLUS COPYRIGHT 2008 ACS on STN

AN 1995:726079 HCAPLUS Full-text

DN 123:113187

OREF 123:20228h,20229a

TI Novel electrically conductive polymer and its manufacture

IN Kato, Junya; Saida, Yoshihiro; Ikenoe, Yoshiaki; Ichikawa, Reiko

PA Showa Denko K. K., Japan

SO Jpn. Kokai Tokkyo Koho, 18 pp.

CODEN: JKXXAF

DT Patent

LA Japanese

FAN.CNT 1

	PATENT NO.	KIND	DATE 	APPLICATION NO.	DATE
ΡΙ	 JP 07048437	А	19950221	JP 1994-122738	199406
	JP 3413958 US 5637652	B2 A	20030609 19970610	US 1994-254691	03

	.TD	2003137981	A	20030514	.TD	2002-321744	199406 06
	OI	2003137901	71	20030314	O1	2002 321744	200211 05
	JΡ	3953939	В2	20070808			
	JР	2007077401	A	20070329	JΡ	2006-294924	
							200610 30
PRAI	JР	1993-134978	А	19930604			
	JP	1994-122738	A3	19940603			
	JP	2002-321744	A3	20021105			
GI							

$$\begin{array}{c|c}
 & (A^{1}Y)m \\
? + Ar \\
 & (Z/j)?f \\
\hline
 & [A^{1}SO_{3}(M)_{f}]_{k} \\
\end{array}$$
I, Ar = asyl

The title elec. conductive polymer contains structural repeating unit I (Φ = specified divalent ring; A1 = single bond or divalent organic group; Y = SO2NR1R2, SO3R3, SO2SR4(R1-4 = specified organic group); M = cation; f = 0, 1; Z = anion; j = 1, 2; δ = 0-1). Manufacture of the above polymer is also claimed. The invention polymer is soluble in organic solvents and water and shows superior processability, high conductivity, and thermal and mech. stability.

IT 152377-26-9DP, reaction product with alkyl amine or aromatic amine, optionally partially desulfonated RL: IMF (Industrial manufacture); PRP (Properties); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses) (preparation of elec. conductive polymers

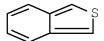
RN 152377-26-9 HCAPLUS

CN Benzo[c]thiophenesulfonic acid, homopolymer (CA INDEX NAME)

CM 1

)

CRN 152377-25-8 CMF C8 H6 O3 S2 CCI IDS

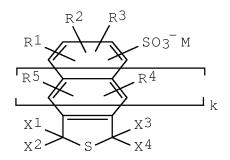


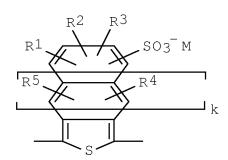
D1-SO3H

```
IC
    ICM C08G061-12
     ICS C08G079-00; H01B001-12
     35-5 (Chemistry of Synthetic High Polymers)
CC
     25233-30-1DP, Polyaniline, sulfonic acid-substituted, reaction
ΙT
     product with n-decylamine 125714-86-5DP, reaction product with
     n-propylamine 135899-67-1DP, reaction product with alkylamine,
     optionally partially desulfonated 141182-90-3DP, reaction product
     with n-amylamine 152313-50-3DP, acidified, reaction product with
     n-octylamine 152377-26-9DP, reaction product with alkyl
     amine or aromatic amine, optionally partially desulfonated
     166032-90-2DP, reaction product with n-octylamine 166032-92-4DP,
     reaction product with n-octylamine
     RL: IMF (Industrial manufacture); PRP (Properties); TEM (Technical
     or engineered material use); PREP (Preparation); USES (Uses)
        (preparation of elec. conductive polymers
        )
L30
    ANSWER 27 OF 33 HCAPLUS COPYRIGHT 2008 ACS on STN
AN
     1995:705298 HCAPLUS Full-text
     123:84317
DN
OREF 123:15107a,15110a
ΤI
    Manufacture of electrically conductive polymers
    Saida, Yoshihiro; Ikenoe, Yoshiaki; Ichikawa, Reiko
ΙN
    Showa Denko K. K., Japan
PA
SO
    Jpn. Kokai Tokkyo Koho, 14 pp.
    CODEN: JKXXAF
DT
    Patent
LA
    Japanese
FAN.CNT 4
    PATENT NO.
                        KIND DATE
                                          APPLICATION NO.
                                                                  DATE
PΙ
    JP 07048436
                        A 19950221 JP 1994-117256
```

199405 30

	JP	3413956	В2	20030609			
	JP	2003261656	A	20030919	JP	2003-25356	
							200302
							03
	JΡ	3825001	В2	20060920			
	JΡ	2006213924	A	20060817	JΡ	2006-60238	
							200603
							06
PRAI	JP	1993-129798	A	19930531			
	JΡ	1994-117256	A3	19940530			
	JΡ	2003-25356	A3	20030203			
GI							





ΙI

AB The process comprises polymerizing a compound I (R1-R5 = H, halo, NO2, amino, C1-20 monovalent organic group; X1-X4 = H, halo; M = H, alkali metal, (substituted) cation of Group VA element; k = 0-3) to give a conjugated π -bond-type elec. conductive polymer containing ≥ 1 structural repeating unit II (R1-R5, M, k as above). The process gives sulfonic acid group-containing elec. conductive (co)polymers with stable conductivity

IT 165455-34-5DP, acidified, optionally partially desulfonated 165455-35-6DP, acidified 165455-37-8P

Ι

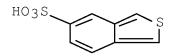
RL: IMF (Industrial manufacture); PRP (Properties); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses) (preparation of elec. conductive polymers

RN 165455-34-5 HCAPLUS

CN Benzo[c]thiophene-5-sulfonic acid, sodium salt, homopolymer (9CI) (CA INDEX NAME)

CM 1

CRN 165455-33-4 CMF C8 H6 O3 S2 . Na



Na

RN 165455-35-6 HCAPLUS

CN Benzo[c]thiophene-5-sulfonic acid, sodium salt, polymer with benzo[c]thiophene (9CI) (CA INDEX NAME)

CM 1

CRN 165455-33-4

CMF C8 H6 O3 S2 . Na

Na

CM 2

CRN 270-82-6 CMF C8 H6 S

CMF C8 H6 S

RN 165455-37-8 HCAPLUS

CN Naphtho[2,3-c]thiophene-6-sulfonic acid, ammonium salt, homopolymer (9CI) (CA INDEX NAME)

CM 1

CRN 165455-36-7 CMF C12 H8 O3 S2 . H3 N

● NH3

RN 165455-41-4 HCAPLUS

CN Benzo[c]thiophene-5-sulfonic acid, 6-(decyloxy)-, sodium salt, homopolymer (9CI) (CA INDEX NAME)

CM 1

CRN 165455-40-3 CMF C18 H26 O4 S2 . Na

Na

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RN
     165455-43-6 HCAPLUS
     Benzo[c]thiophene-5-sulfonic acid, 1,3-dichloro-, ammonium salt,
CN
     homopolymer (9CI) (CA INDEX NAME)
          1
     CM
     CRN 165455-42-5
     CMF C8 H4 C12 O3 S2 . H3 N
 HO3S
        €НИ ●
IC
     ICM C08G061-12
     TCS H01B001-12
CC
     35-4 (Chemistry of Synthetic High Polymers)
ΙT
     165455-34-5DP, acidified, optionally partially desulfonated
     165455-35-6DP, acidified 165455-37-8P
     RL: IMF (Industrial manufacture); PRP (Properties); TEM (Technical
     or engineered material use); PREP (Preparation); USES (Uses)
        (preparation of elec. conductive polymers
     165455-41-4DP, acidified 165455-43-6P
ΙT
     RL: IMF (Industrial manufacture); TEM (Technical or engineered
     material use); PREP (Preparation); USES (Uses)
        (preparation of elec. conductive polymers
        )
L30
    ANSWER 28 OF 33 HCAPLUS COPYRIGHT 2008 ACS on STN
     1995:498326 HCAPLUS Full-text
AN
DN
     122:251969
OREF 122:45757a,45760a
ΤI
     Antistatic silver halide photographic material
    Tachibana, Noriki; Morita, Seiwa
ΙN
    Konishiroku Photo Ind, Japan
PΑ
SO
     Jpn. Kokai Tokkyo Koho, 47 pp.
     CODEN: JKXXAF
```

DT Patent

LA Japanese

FAN.CNT 1

	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
ΡI	JP 06301154	A	19941028	JP 1993-87395	
					199304
					1 4

PRAI JP 1993-87395

19930414

AB In the title Ag halide photog. material utilizing ≥ 1 antistatic layers containing an electronically conductive polymer, the above polymer is crosslinked with a crosslinking agent selected from an epoxy-, aldehyde-, reactive ethylene-, ethyleneimine-, reactive ester-type material.

IT 91201-85-3 133150-75-1 133184-17-5 162370-00-5

RL: DEV (Device component use); TEM (Technical or engineered material use); USES (Uses)

(electronically conductive polymer;

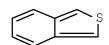
antistatic photog. film using)

RN 91201-85-3 HCAPLUS

CN Benzo[c]thiophene, homopolymer (CA INDEX NAME)

CM 1

CRN 270-82-6 CMF C8 H6 S



RN 133150-75-1 HCAPLUS

CN Benzo[c]thiophene, 5-octyl-, homopolymer (9CI) (CA INDEX NAME)

CM 1

CRN 133150-74-0 CMF C16 H22 S

RN 133184-17-5 HCAPLUS

CN Benzo[c]thiophene, 5-ethyl-, homopolymer (9CI) (CA INDEX NAME)

CM 1

CRN 133184-16-4 CMF C10 H10 S

RN 162370-00-5 HCAPLUS

CN Benzo[c]thiophene, 5-[(octyloxy)methyl]-, homopolymer (9CI) (CA INDEX NAME)

CM 1

CRN 162369-99-5 CMF C17 H24 O S

IC ICM G03C001-89

ICS G03C001-04; G03C001-30

CC 74-2 (Radiation Chemistry, Photochemistry, and Photographic and Other Reprographic Processes)

IT 25233-30-1 25233-34-5 25265-93-4 25988-40-3 30604-81-0 91201-85-3 95831-23-5 110847-38-6 132670-08-7 132910-05-5 133150-75-1 133184-17-5

```
162370-00-5 162370-01-6
    RL: DEV (Device component use); TEM (Technical or engineered
    material use); USES (Uses)
        (electronically conductive polymer;
       antistatic photog. film using)
    ANSWER 29 OF 33 HCAPLUS COPYRIGHT 2008 ACS on STN
L30
AN
    1995:446542 HCAPLUS Full-text
DN
    122:214911
OREF 122:39305a,39308a
ΤI
    Manufacture of electric conductive polymers
    Saida, Yoshihiro; Ichikawa, Reiko; Kato, Junya; Ikenoe, Yoshiaki
ΙN
    Showa Denko Kk, Japan
PA
    Jpn. Kokai Tokkyo Koho, 14 pp.
SO
    CODEN: JKXXAF
DT
    Patent
LA
    Japanese
FAN.CNT 1
    PATENT NO.
                       KIND DATE
                                         APPLICATION NO.
                                                                 DATE
    _____
                       ____
                               _____
                                          ______
     _____
PΙ
    JP 06256516
                        Α
                              19940913
                                         JP 1993-73021
                                                                 199303
                                                                 08
    JP 3149290
                               20010326
                        В2
    JP 2001187822
                         А
                               20010710
                                         JP 2000-359053
                                                                 200011
                                                                 27
    JP 3310267
                        В2
                               20020805
PRAI JP 1993-73021
                         А3
                               19930308
     Elec. conductive polymers are manufactured by treating benzothiophene
AB
     polymers with sulfonating agents.
     Poly(1,3-dihydrobenzothiophene-1,3-diyl) was treated with fuming
     sulfuric acid to provide a elec. conductive polymer. Elec.
     conductive material can also be obtained by treating a polymer blend
     containing benzothiophene polymers and other polymers, such as
     polyethylene, with sulfonating agents.
ΙΤ
     91201-86-4DP, reaction products with sulfuric acid
    RL: IMF (Industrial manufacture); TEM (Technical or engineered
    material use); PREP (Preparation); USES (Uses)
        (manufacture of elec. conductive polymers
       )
RN
    91201-86-4 HCAPLUS
    Poly(1,3-dihydrobenzo[c]thiophene-1,3-diyl) (9CI) (CA INDEX NAME)
CN
```

137539-66-3 162369-94-0 162369-96-2 162369-98-4

```
IC
    ICM C08G075-00
     ICS C08L057-06; C09K003-16; H01B001-12
    35-8 (Chemistry of Synthetic High Polymers)
CC
    Section cross-reference(s): 76
    7664-93-9DP, Sulfuric acid, reaction products with
ΙT
    polydihydroisothianaphthenylenes 91201-86-4DP, reaction
     products with sulfuric acid 133881-09-1DP, reaction products with
     sulfuric acid 161937-24-2DP, reaction products with sulfuric acid
     RL: IMF (Industrial manufacture); TEM (Technical or engineered
     material use); PREP (Preparation); USES (Uses)
        (manufacture of elec. conductive polymers
        )
L30
    ANSWER 30 OF 33 HCAPLUS COPYRIGHT 2008 ACS on STN
    1994:568301 HCAPLUS Full-text
ΑN
    121:168301
DN
OREF 121:30293a,30296a
   Electrically conductive polymeric compositions
ΤI
    Hedges, Winston Lee
ΙN
PA
    Hexcel Corp., USA
    PCT Int. Appl., 48 pp.
SO
    CODEN: PIXXD2
DT
    Patent
    English
LA
FAN.CNT 3
    PATENT NO.
                       KIND DATE
                                         APPLICATION NO.
                                                                DATE
PΙ
    WO 9411885
                        A1 19940526
                                         WO 1993-US6494
                                                                 199307
                                                                 08
        W: CA, JP
        RW: AT, BE, CH, DE, DK, ES, FR, GB, GR, IE, IT, LU, MC, NL, PT,
PRAI US 1992-972574 A 19921106
```

OS MARPAT 121:168301

AB The compns. are suitable for fabricating devices for safely transporting volatile chems. and fuels. The compns. include ≥1 matrix polymer and an elec. conductive filler material incorporated in the matrix polymer in an amount sufficient to provide the conductive polymeric composition with an elec. conductivity of ≥10-10S/cm. The filler material is intrinsically conductive polymer-coated C particles. The coating of intrinsically elec. conductive polymer provides a protective shield against loss of particle conductivity and contributes to the overall conductivity of the filler material.

IT 91201-85-3, Polyisothianaphthene

RL: USES (Uses)

(elec. conductive polymer compns.

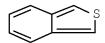
containing)

RN 91201-85-3 HCAPLUS

CN Benzo[c]thiophene, homopolymer (CA INDEX NAME)

CM 1

CRN 270-82-6 CMF C8 H6 S



IC ICM H01B001-00 ICS H01B001-20; H01B001-24; H01B005-00

CC 76-2 (Electric Phenomena)
Section cross-reference(s): 38

98-11-3, Benzenesulfonic acid, uses ΙT 75-75-2, Methanesulfonic acid 7440-44-0, Carbon, uses 7664-38-2, Phosphoric 104-15-4, uses acid, uses 7664-93-9, Sulfuric acid, uses 9002-84-0, Teflon 9002-86-2, Polyvinyl chloride 9002-88-4, Polyethylene Polypropylene 9003-53-6, Polystyrene 9003-55-8, Butadiene styrene copolymer 9033-83-4, Polyphenylene 24937-78-8, Polyethylene vinyl acetate 25014-41-9, Polyacrylonitrile 25067-58-7, Polyacetylene 25067-54-3, Polyfuran 25233-30-1, 25233-34-5, Polythiophene 30604-81-0, Polypyrrole Polvaniline 82451-56-7, Polyazulene 91201-85-3, 70191-75-2 Polyisothianaphthene 96638-49-2, Polyphenylenevinylene 157710-50-4, Calfax 10LA40

RL: USES (Uses)

(elec. conductive polymer compns.

containing)

L30 ANSWER 31 OF 33 HCAPLUS COPYRIGHT 2008 ACS on STN

AN 1989:96028 HCAPLUS Full-text

DN 110:96028

OREF 110:15889a,15892a

TI Manufacture of conductive polymers having isothianaphthene rings

IN Uotani, Nobuo; Yoshida, Haruo

PA Showa Denko K. K., Japan

SO Jpn. Kokai Tokkyo Koho, 5 pp.

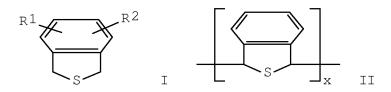
CODEN: JKXXAF

DT Patent

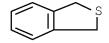
LA Japanese

FAN.CNT 1

	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
PI	JP 63118323	А	19880523	JP 1986-262803	198611 06
PRAI OS GI	JP 07039477 JP 1986-262803 MARPAT 110:96028	В	19950501 19861106		



AB Elec. conductive title polymers are prepared in high yield in a single step by oxidative polymerization of dihydroisothianaphthenes I (R1-2 = H, C1-5 hydrocarbyl). Thus, 4.1 g 1,3-dihydroisothianaphthene was polymerized in N-methyl-2-pyrrolidone containing 17.0 g 2,3-dichloro-5,6-dicyano-1,4-benzoquinone at 130° for 10 h to give 3.9 g blue-black polymer II, whose IR spectrum was identical to that of II prepared by electrochem. polymerization of isothianaphthene. II had elec. conductivity 9 + 10-3 S/cm initially, and 8 + 19-1 S/cm after doping overnight in I2 vapor.



L30 ANSWER 32 OF 33 HCAPLUS COPYRIGHT 2008 ACS on STN

AN 1988:159870 HCAPLUS Full-text

DN 108:159870

OREF 108:26101a,26104a

TI Electrically conductive polymers with improved mechanical strength and light transmittance

IN Tanaka, Shinsuke; Sada, Toshikatsu

PA Japan

SO Jpn. Kokai Tokkyo Koho, 4

CODEN: JKXXAF

DT Patent

LA Japanese

FAN.CNT 1

	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
ΡI	JP 62292855	А	19871219	JP 1986-136154	

198606

84(5), 627-32

CODEN: JCPBAN; ISSN: 0021-7689

PRAI JP 1986-136154 19860613 Organic polymers dispersed with polyisothianaphthenes and dopants show excellent conductivity, mech. strength, and light transmittance. An electrochem. oxidative polymerization of isobenzothiophene on a PVC-coated Pt plate in MeCN containing Et4NClO4 at 5 mA/cm2 gave a light-transmitting, elec. conductive polymer film. 91201-85-3, Polyisothianaphthene ΙT RL: USES (Uses) (elec. conductive polymers dispersed with dopants and, light-transmitting) 91201-85-3 HCAPLUS RNCN Benzo[c]thiophene, homopolymer (CA INDEX NAME) CM 1 CRN 270-82-6 CMF C8 H6 S IC ICM C08L101-00 ICS C08K003-16; C08K005-17; C08K005-42; C08K005-45; H01B001-12 76-2 (Electric Phenomena) CC Section cross-reference(s): 35, 38, 72, 73 91201-85-3, Polyisothianaphthene ΙT RL: USES (Uses) (elec. conductive polymers dispersed with dopants and, light-transmitting) L30 ANSWER 33 OF 33 HCAPLUS COPYRIGHT 2008 ACS on STN 1987:637615 HCAPLUS Full-text AN 107:237615 DN OREF 107:38195a,38198a Molecular engineering of organic polymers with a very small ΤI intrinsic bandgap: a theoretical approach ΑU Bredas, J. L. Cent. Rech. Mater. Av., Univ. Notre-Dame de la Paix, Namur, B-5000, CS Journal de Chimie Physique et de Physico-Chimie Biologique (1987), SO

DT Journal

LA English

Theor. calcns. aimed at designing new organic polymers which would be intrinsically elec. conductors are presented. For aromatic polymers such as polythiophene, a linear relationship was established between the bandgap value and the importance of quinoid contributions to the geometry. The electronic properties of polyisothianaphthene as well as polythieno[3,4-c]thiophene, and polyisonaphthothiophene were described. The conditions leading to a very small bandgap in the latter 2 compds. were discussed.

IT 91201-85-3 107949-39-3, Polyisonaphthothiophene

RL: PRP (Properties)

(bandgap of, mol. engineering of elec.

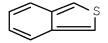
conducting polymers in relation o)

RN 91201-85-3 HCAPLUS

CN Benzo[c]thiophene, homopolymer (CA INDEX NAME)

CM 1

CRN 270-82-6 CMF C8 H6 S

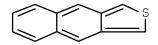


RN 107949-39-3 HCAPLUS

CN Naphtho[2,3-c]thiophene, homopolymer (9CI) (CA INDEX NAME)

CM 1

CRN 268-55-3 CMF C12 H8 S



=> d 129 bib abs hitstr hitind retable tot

L29 ANSWER 1 OF 3 HCAPLUS COPYRIGHT 2008 ACS on STN

AN 2002:810015 HCAPLUS Full-text

DN 138:73639

TI Synthesis and properties of new aromatic poly(amine-imide)s derived from N,N'-bis(4-aminophenyl)-N,N'-diphenyl-1,4-phenylenediamine

AU Liou, Guey-Sheng; Hsiao, Sheng-Huei; Ishida, Mina; Kakimoto, Masaaki; Imai, Yoshio

CS Department of Applied Chemistry, National Chi Nan University, Hsien, 545, Taiwan

Journal of Polymer Science, Part A: Polymer Chemistry (2002), 40(21), 3815-3822 CODEN: JPACEC; ISSN: 0887-624X

PB John Wiley & Sons, Inc.

DT Journal

LA English

A series of new triphenylamine-containing aromatic poly(amine-imide)s AB were synthesized either by a conventional 2-step process from N, N'bis(4-aminophenyl)-N,N'-diphenyl-1,4-phenylenediamine with various aromatic tetracarboxylic dianhydrides or by the 1-step thioanhydride method from the diamine with aromatic tetracarboxylic dithioanhydrides. Obtained polymers were cast into films and examined on their inherent viscosity, solubility, thermal and mech. properties as well as morphol. In the 2-step process, the precursor polyamic acids obtained in the 1st stage had inherent viscosities between 0.71-1.86 dL/q. Except for the poly(amine-imide) from the pyromellitic dianhydride, all the other poly(amine-imide)s dissolve in N-methyl-2-pyrrolidone, and several poly(amine-imide)s also exhibited good solubility in other organic solvents. All the poly(amine-imide)s were amorphous as evidenced by x-ray diffractograms. These polymers could afford tough and flexible films with good mech. properties. They had relative high glass transition temps. $(274-332^\circ)$, 10% weight-loss temps. >560° in both N2 and air atmospheres, and char yields at 800° in N2 higher than 63%.

IT 480435-51-6P

RL: PRP (Properties); SPN (Synthetic preparation); PREP (Preparation)

(preparation and properties of aromatic poly(amine-imide)s derived

from

p-bis[(aminophenyl)(phenyl)amino]benzene and tetracarboxylic
dithioanhydrides)

RN 480435-51-6 HCAPLUS

CN Benzo[c]thiophene-1,3-dione, 5,5'-sulfonylbis-, polymer with N,N'-bis(4-aminophenyl)-N,N'-diphenyl-1,4-benzenediamine (9CI) (CA INDEX NAME)

CM 1

CRN 141680-38-8 CMF C16 H6 O6 S3

CM 2

ΙT

from

CRN 111341-76-5 CMF C30 H26 N4

CC 35-5 (Chemistry of Synthetic High Polymers)

480435-48-1P 480435-49-2P 480435-50-5P 480435-51-6P

RL: PRP (Properties); SPN (Synthetic preparation); PREP (Preparation)

(preparation and properties of aromatic poly(amine-imide)s derived

p-bis[(aminophenyl)(phenyl)amino]benzene and tetracarboxylic

dithioanhydrid				
Referenced Author	Year VOI	J PG	Referenced Work	
Referenced	(DDM) (DM	\	(157.777)	1 7416
(RAU)	(RPY) (RVI		(RWK)	File
==		+	_+	-+
Anon	1990	227	Polyimides	I
Anon	1996	1309	Polyimides: Fundame	า าไ
Eastmond, G	11999 40	1469	Polymer	HCAPLUS
Hsiao, S	11998 31	7213	Macromolecules	HCAPLUS
Imai, Y	1995 7	1337	High Perform Polym	HCAPLUS
Imai, Y	1972 10	2091	J Polym Sci Part A-	•
Imai, Y	1984 22	2189	J Polym Sci Polym Cl	
Imai, Y	1996 1	1404	Polym Mater Encycl	
Imai, Y	1989 28	371	Polym Plast Technol	 HCAPLUS
Imai, Y	11996 30	13	React Funct Polym	
Jeong, H	1991 29	11691	• -	HCAPLUS
Jeong, H	1991 29	139	J Polym Sci Part A:	HCAPLUS
Ko, C	2002 126	137	Synth Met	HCAPLUS
Koene, B	1998 10	12235	Chem Mater	HCAPLUS
Liou, G	1998 36	11937	'	HCAPLUS
Liou, G	2001 39	11786	J Polym Sci Part A:	HCAPLUS
Liou, G	12002 40	2810	J Polym Sci Part A:	HCAPLUS
Lu, J	1999 11	12501	Chem Mater	HCAPLUS
Oishi, Y	1992 30	11027	'	HCAPLUS
Shirota, Y		-1 387	Synth Met	HCAPLUS
Wu, A	1996 3	13	Supramol Sci	HCAPLUS
, 22	1 1 3 3 3 1 5	10	Todificanter Sol	1110111 200
L29 ANSWER 2 OF 3 HC	APLUS COPYF	RIGHT 20	08 ACS on STN	
AN 1992:409111 HCAF	LUS <u>Full-te</u>	ext		
DN 117:9111				
OREF 117:1811a,1814a				

TI Soluble aromatic polyimides having high glass transition temperature

IN Imai, Yoshio; Kakimoto, Masaaki; Oishi, Yoshiyuki; Ishida, Mina

PA Mitsubishi Kasei Corp., Japan

SO Jpn. Kokai Tokkyo Koho, 7 pp.

CODEN: JKXXAF

DT Patent

LA Japanese

FAN.CNT 1

	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
ΡI	JP 04011631	А	19920116	JP 1990-113707	

199004

PRAI JP 1990-113707 19900427

AB Polyimides having intrinsic viscosity 0.1-5 dL/g as determined at 30° in H2SO4 are prepared from aromatic tetracarboxylic acid dianhydrides such as pyromellitic dianhydride (I), 3,4,3',4'-benzophenonetetracarboxylic dianhydride, etc. and triphenyldiamine. Thus, a 4,4'-diaminotriphenylamine-I copolymer was prepared, which had 10% weight loss temperature 570° in air and 600° in N.

IT 141680-39-9

RL: USES (Uses)

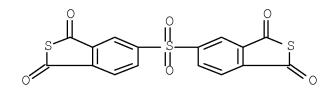
(films, heat-resistant and soluble)

RN 141680-39-9 HCAPLUS

CN Benzo[c]thiophene-1,3-dione, 5,5'-sulfonylbis-, polymer with N-(4-aminophenyl)-N-phenyl-1,4-benzenediamine (9CI) (CA INDEX NAME)

CM 1

CRN 141680-38-8 CMF C16 H6 O6 S3



CM 2

CRN 4117-90-2 CMF C18 H17 N3

IC ICM C08G073-10

CC 37-3 (Plastics Manufacture and Processing)

IT 34873-51-3, 4,4'-Diaminotriphenylamine-pyromellitic dianhydride

L29

AN

DN

ΤI

ΑU

CS SO

DT

LA

AB

ΙT

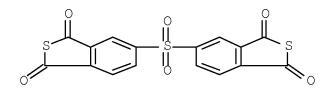
RN

CN

```
copolymer 36812-70-1 101060-74-6 101060-99-5 112409-97-9
     112409-98-0
                  112410-17-0
                                112410-18-1
                                              118229-54-2
                                                             128509-00-2
    141656-78-2
                  141680-37-7 141680-39-9 141680-40-2
    141680-41-3 141680-42-4
    RL: USES (Uses)
        (films, heat-resistant and soluble)
    ANSWER 3 OF 3 HCAPLUS COPYRIGHT 2008 ACS on STN
    1992:408606 HCAPLUS Full-text
    117:8606
OREF 117:1739a,1742a
    Preparation and properties of novel soluble aromatic polyimides from
     4,4'-diaminotriphenylamine and aromatic tetracarboxylic dianhydrides
    Oishi, Yoshiyuki; Ishida, Mina; Kakimoto, Masaaki; Imai, Yoshio;
    Kurosaki, Toshikazu
    Dep. Org. Polym. Mater., Tokyo Inst. Technol., Tokyo, 152, Japan
    Journal of Polymer Science, Part A: Polymer Chemistry (1992),
    30(6), 1027-35
    CODEN: JPACEC; ISSN: 0887-624X
    Journal
    English
     Aromatic polyimides containing triphenylamine units were prepared by
     two different methods, i.e., a conventional 2-step procedure starting
     from 4,4'-diaminotriphenylamine (I) and aromatic tetracarboxylic
     dianhydrides and a 1-step thioanhydride method from I and aromatic
     tetracarboxylic dithioanhydrides. Both procedures yielded high-mol.-
     weight polyimides with inherent viscosities 0.47-1.17 dL/g. Some of
     these polymers were soluble in organic solvents such as AcNMe2, N-
     methyl-2-pyrrolidone, m-cresol, and pyridine. All the polyimides
     afforded transparent, flexible, and tough films, and the color varied
     from pale yellow to dark red, depending markedly on the
     tetracarboxylic acid components. The glass transition temps. (Tg) of
     these polyimides were 287-331° and the 10% weight loss temps. were
     >520° in air. The polyimides prepared by the 1-step method exhibited
     better solubility in organic solvents and had somewhat lower Tg than
     the polymers prepared by the conventional 2-step method.
     141680-39-9P
    RL: PRP (Properties); SPN (Synthetic preparation); PREP
     (Preparation)
        (preparation and thermal properties of)
    141680-39-9 HCAPLUS
    Benzo[c]thiophene-1,3-dione, 5,5'-sulfonylbis-, polymer with
    N-(4-aminophenyl)-N-phenyl-1,4-benzenediamine (9CI) (CA INDEX NAME)
    CM
         1
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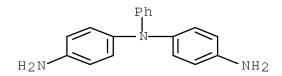
141680-38-8 CRN

CMF C16 H6 O6 S3



CM 2

CRN 4117-90-2 CMF C18 H17 N3



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CC 35-5 (Chemistry of Synthetic High Polymers)
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IT 34873-51-3P 36812-70-1P 101060-74-6P 101060-99-5P 112409-97-9P 112409-98-0P 112410-17-0P 112410-18-1P 118229-54-2P 128509-00-2P 141656-78-2P 141680-37-7P 141680-39-9P 141680-40-2P 141680-41-3P 141680-42-4P 141897-63-4P

RL: PRP (Properties); SPN (Synthetic preparation); PREP (Preparation)

(preparation and thermal properties of)

=>